

# Modeling, Design and Optimization of On-Chip Inductors and Transformers

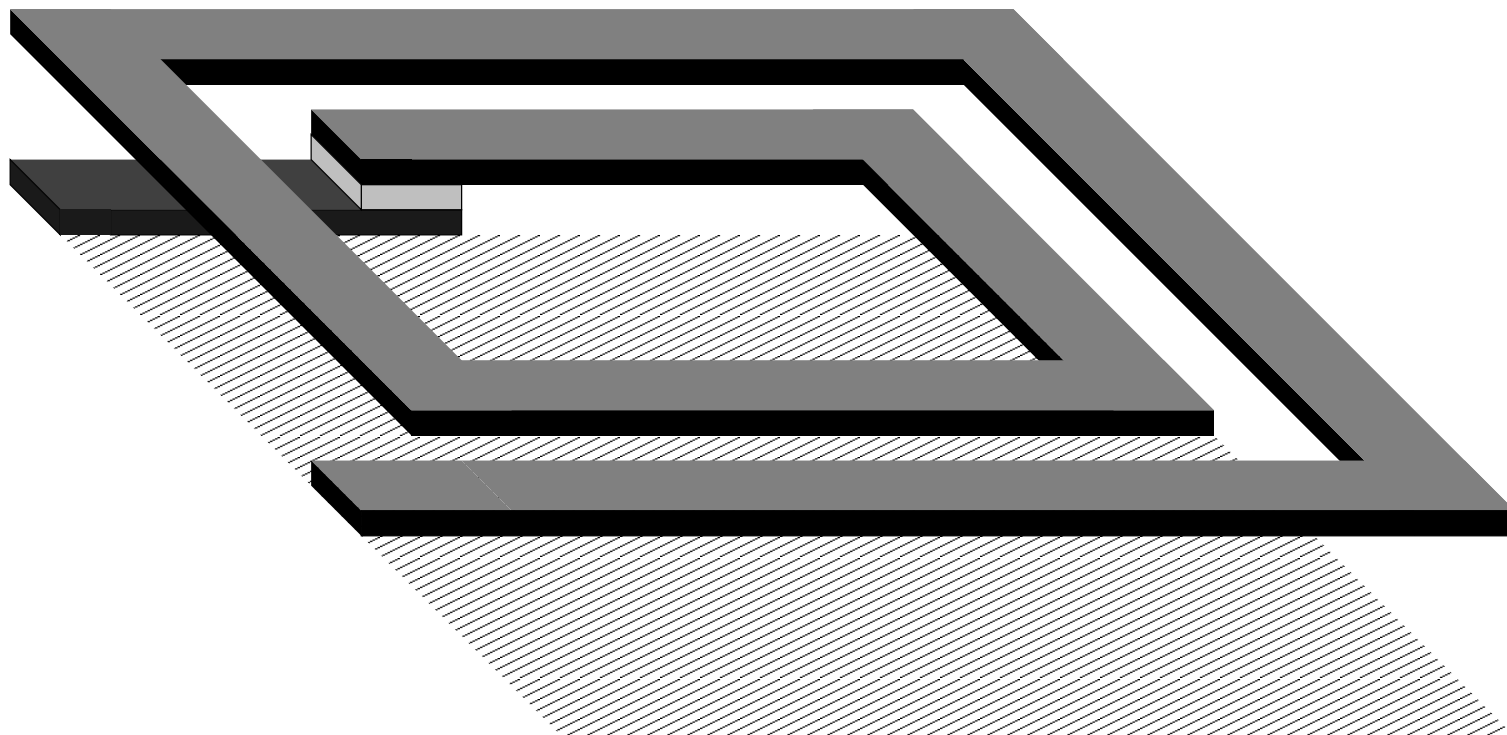
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# THE GOAL

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**Simple, Accurate Expressions for Inductance**

# OUTLINE

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- Background
- Current Sheet Approach
- Accurate Inductance Expressions
- Optimization of Inductor Circuits
- Transformer Modeling
- Contributions

# ON-CHIP INDUCTORS AND TRANSFORMERS

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- Essential for radio frequency integrated circuits (RFICs)
- Narrowband circuits
  - { Low noise amplifiers, oscillators, filters, matching networks, baluns
- Broadband circuits
  - { Shunt-peaking to enhance bandwidth

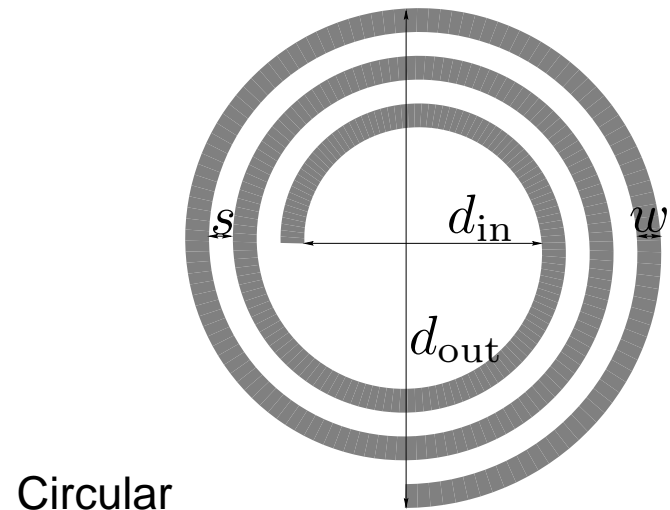
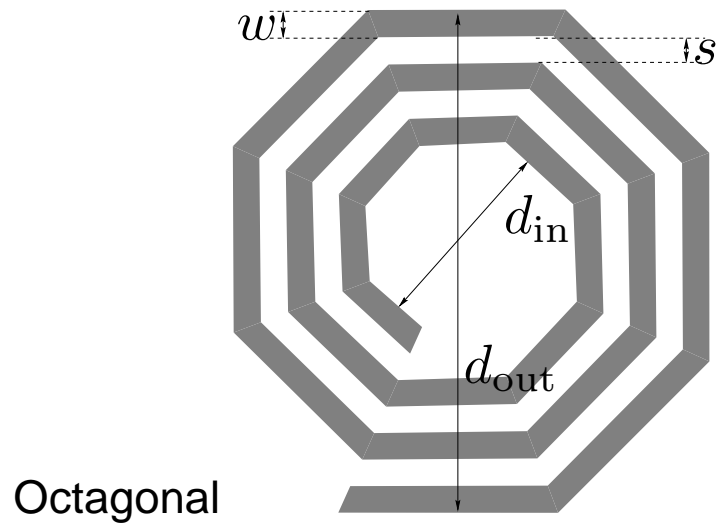
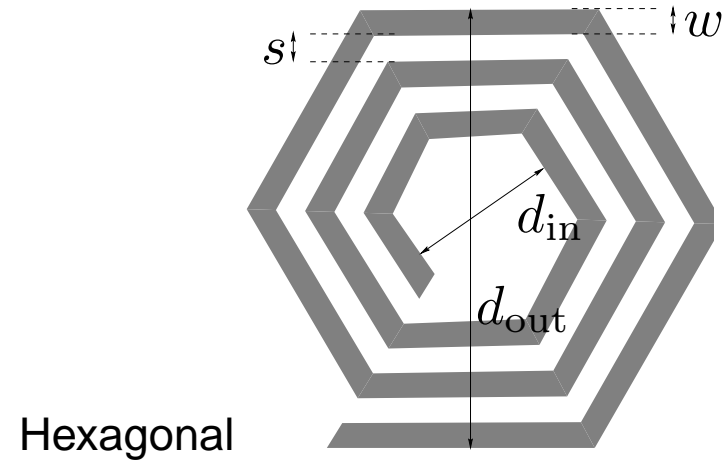
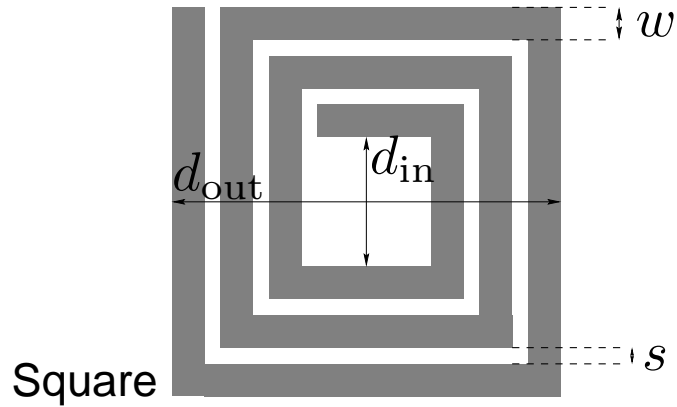
## ON-CHIP INDUCTOR OPTIONS

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<b>Attribute</b>	<b>Bond wire</b>	<b>Planar Spiral</b>
<b>Inductance</b>	0.5 – 4nH	0.2 – 100nH
<b>Q</b>	30 – 60	< 10
<b>Parasitics</b>	$C_{\text{Bondpad}}$	$R_s, C_{\text{ox}}, C_{\text{si}}, R_{\text{si}}$
<b>Fluctuations</b>	Large	Small

# LATERAL PARAMETERS

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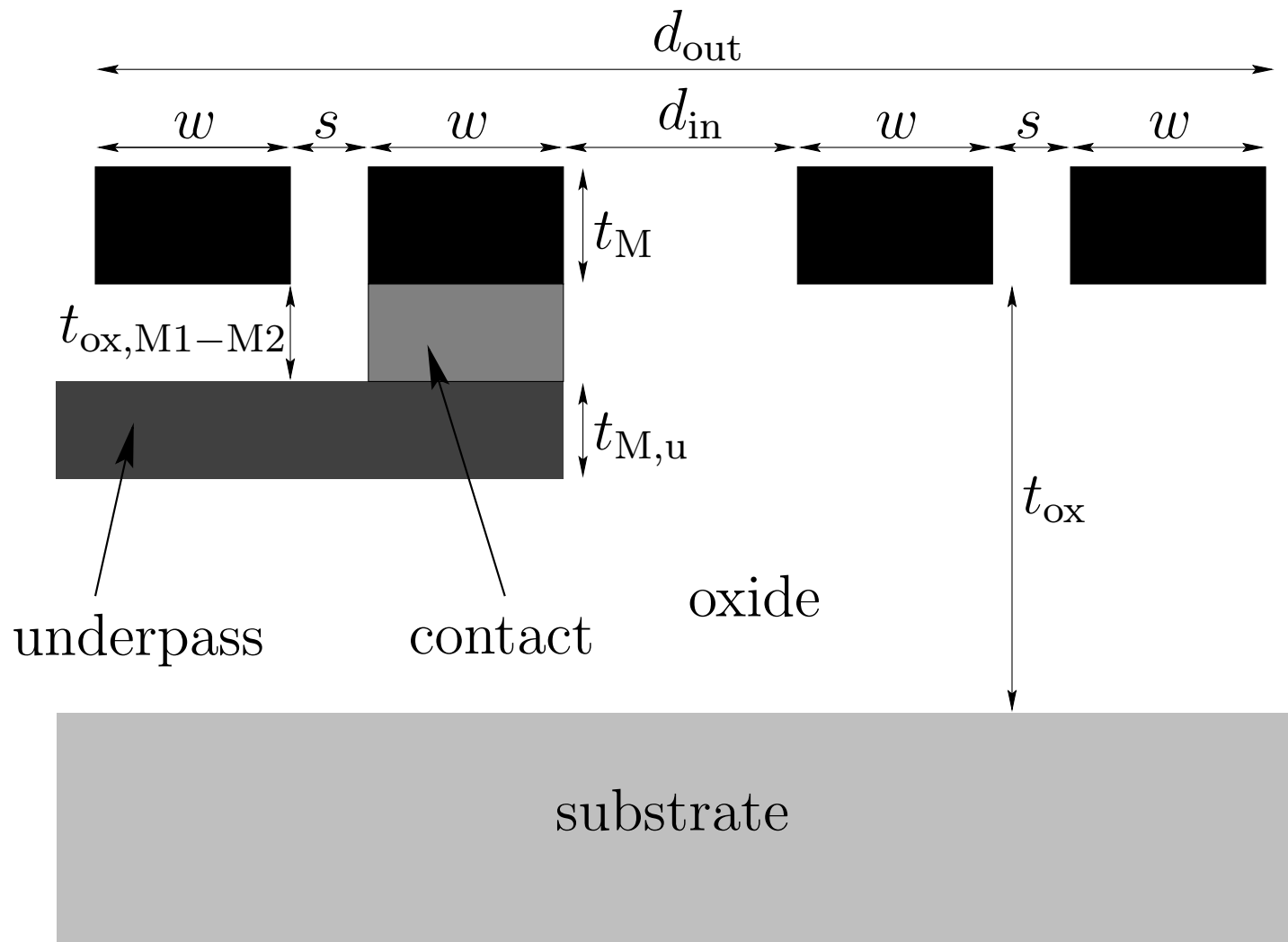
## LATERAL PARAMETERS

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1. Shape: square, hexagonal, octagonal, . . .
2. Number of turns,  $n$
3. Conductor width,  $w$
4. Conductor spacing,  $s$
5.  $d_{\text{out}}, d_{\text{in}}, d_{\text{avg}} = 0.5(d_{\text{out}} + d_{\text{in}})$ , or  $\rho = \frac{d_{\text{out}} - d_{\text{in}}}{d_{\text{out}} + d_{\text{in}}}$

# VERTICAL PARAMETERS

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# MODELING APPROACHES

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- 3-D field solvers
- Segmented models
- Lumped, Scalable models

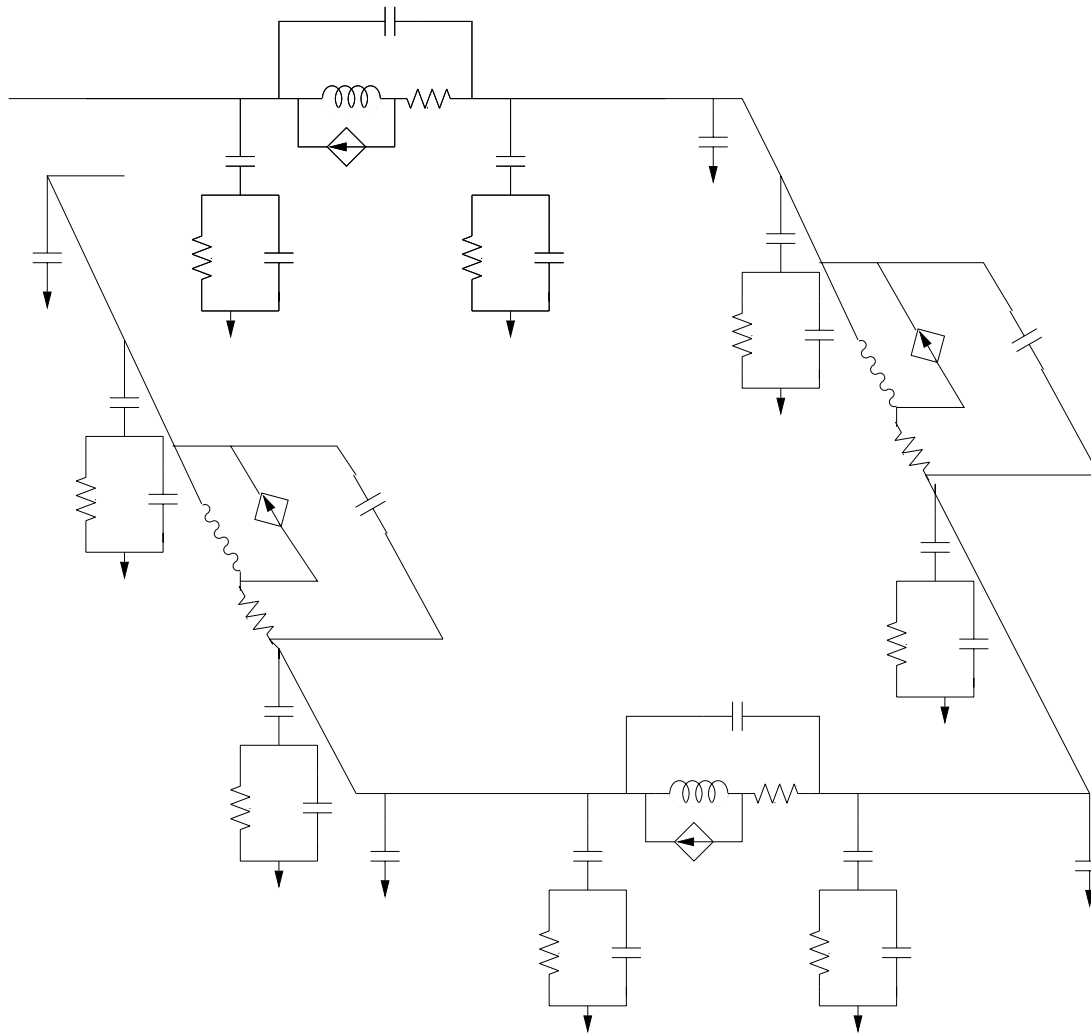
## 3-D FIELD SOLVERS

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- General Purpose Tools
  - { Solve Maxwell's equations numerically
  - { **Accurate**, but **slow** and **memory intensive**
  - { Examples: *Maxwell*, *MagNet*
- Custom Tools for Spiral Inductors and Transformers
  - { Electrostatic and Magnetostatic approximations
  - { Good for **verification**, but **inconvenient** for circuit **design** and **synthesis**
  - { Examples: *ASITIC*, *SPIRAL*

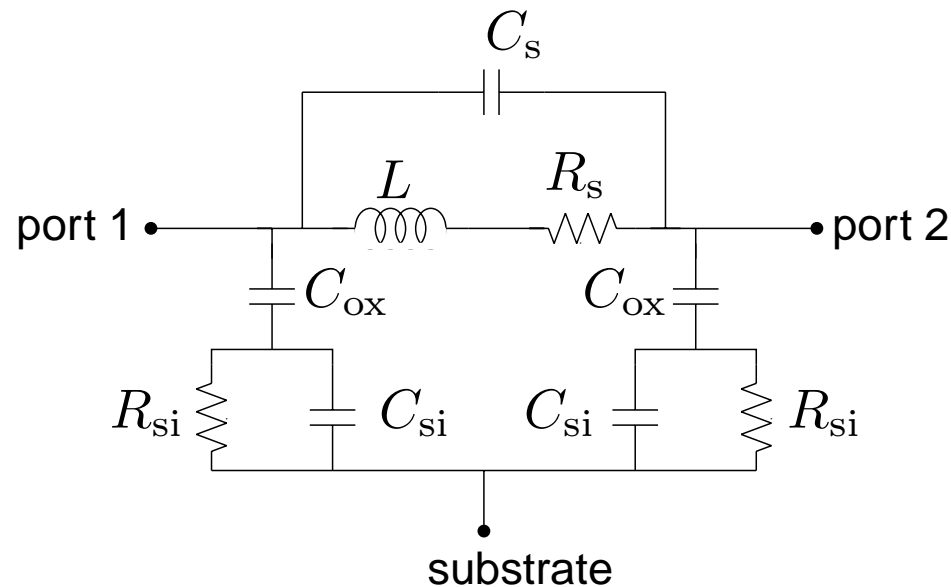
# SEGMENTED MODELS

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# LUMPED, SCALABLE MODELS

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- Simple expressions for  $R_s$ ,  $C_{ox}$  and  $C_s$
- **NEED** simple, accurate expression for inductance!
- Limitations:
  - { Magnetic coupling to substrate **NOT** modeled
  - { Lumped approximation not valid beyond self-resonant frequency

# GREENHOUSE APPROACH

Find self inductance of, and mutual inductance between every segment of spiral:

$$\mathcal{M}_{gen,i,j} = \begin{bmatrix} L_1 & M_{1,2} & \dots & M_{1,(n-1)} & M_{1,n} \\ M_{1,2} & L_2 & \dots & M_{2,(n-1)} & M_{2,n} \\ \dots & \dots & \dots & \dots & \dots \\ M_{1,(n-1)} & M_{2,(n-1)} & \dots & L_{(n-1)} & M_{n,(n-1)} \\ M_{1,n} & M_{2,n} & \dots & M_{n,(n-1)} & L_n \end{bmatrix}$$

$$L_T = \sum_{i=1}^n L_i + \sum_{i=1}^n \sum_{j=1, j \neq i}^n M_{i,j}$$

## PREVIOUSLY REPORTED EXPRESSIONS

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$$\text{Voorman : } L_{\text{voo}} = 10^{-3} n^2 d_{\text{avg}}$$

$$\text{Dill : } L_{\text{dil}} = 8.5 \cdot 10^{-4} n^{5/3} d_{\text{avg}}$$

$$\text{Bryan : } L_{\text{bry}} = 2.41 \cdot 10^{-3} n^{5/3} d_{\text{avg}} \log(4/\rho)$$

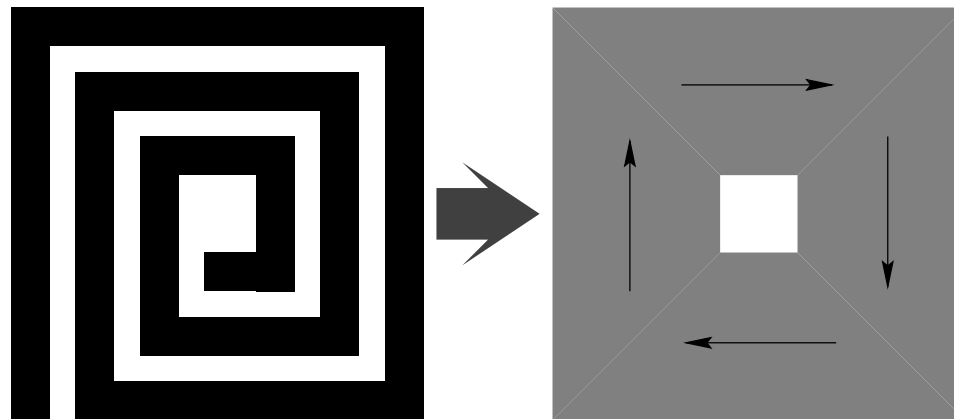
$$\text{Ronkanien : } L_{\text{ron}} = 1.5 \mu_0 n^2 e^{-3.7(n-1)(w+s)/d_{\text{out}}}$$

$$\text{Crols : } L_{\text{cro}} = 1.3 \cdot 10^{-4} (d_{\text{out}}^3/w^2) \eta_a^{5/3} \eta_w^{1/4}$$

- Empirical expressions
- Significant mean offset errors
- Even when corrected, errors  $> 15 - 20\%$

## DERIVATION OF ACCURATE EXPRESSIONS

- Use equivalent current sheet to simplify problem:



- Use GMD, AMD and AMSD to derive simple expression

## GEOMETRIC MEAN DISTANCE (GMD)

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- For distances  $d_1$  and  $d_2$ :

$$\text{GMD} = \sqrt{d_1 d_2}$$

$$\ln(\text{GMD}) = \frac{1}{2} [\ln(d_1) + \ln(d_2)]$$

- For  $n$  distances:

$$\ln(\text{GMD}) = \frac{1}{n} [\ln(d_1) + \ln(d_2) \cdots + \ln(d_n)]$$



# GMD IN INDUCTANCE CALCULATIONS

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- Need to evaluate of GMD of conductor cross-section(s):
  - { Self: GMD of conductor cross-section from itself
  - { Mutual: GMD between two conductor cross-sections
- Use continuous variable definition of GMD
  - { Need integrals rather than sums
- GMD introduced in to inductance calculations by J. C. Maxwell

## GMD IN INDUCTANCE CALCULATIONS

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- For cross sections in one dimension (current sheets):

$$l_1 l_2 \ln(\text{GMD}) = \iint \ln(r) dx dx'$$

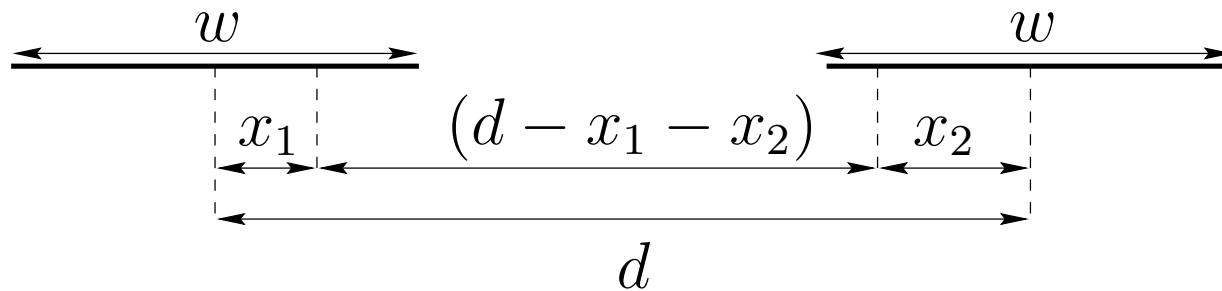
{  $l_1$  and  $l_2$  are the lengths of the cross-sections

{  $dx$  and  $dx'$  are the elements of the cross-sections

{  $r$  is the distance between the elements

# GMD BETWEEN TWO LINES

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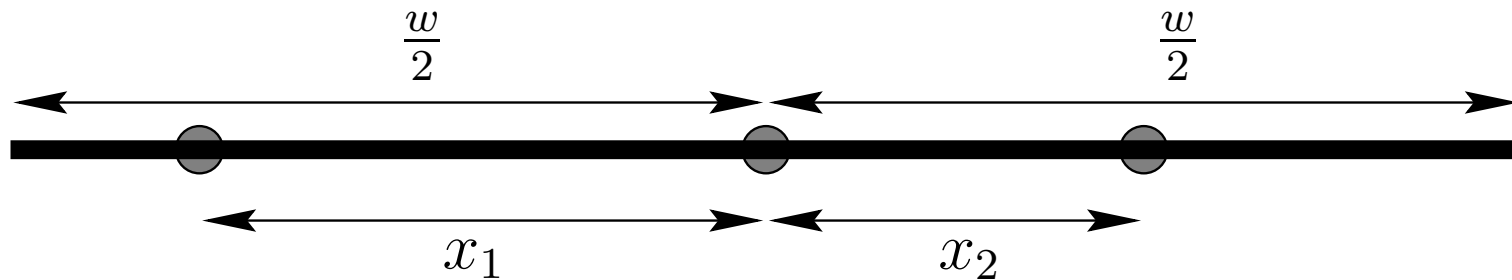


$$\begin{aligned}\ln(\text{GMD}) &= \frac{1}{w^2} \int_{-0.5w}^{0.5w} \int_{-0.5w}^{0.5w} \ln |d - x_1 - x_2| dx_1 dx_2 \\ &\approx \ln(d) - \frac{w^2}{12d^2} - \frac{w^4}{60d^4} \cdots\end{aligned}$$

- Basis for mutual inductance calculations in Greenhouse method

# GMD, AMD AND AMSD OF A LINE

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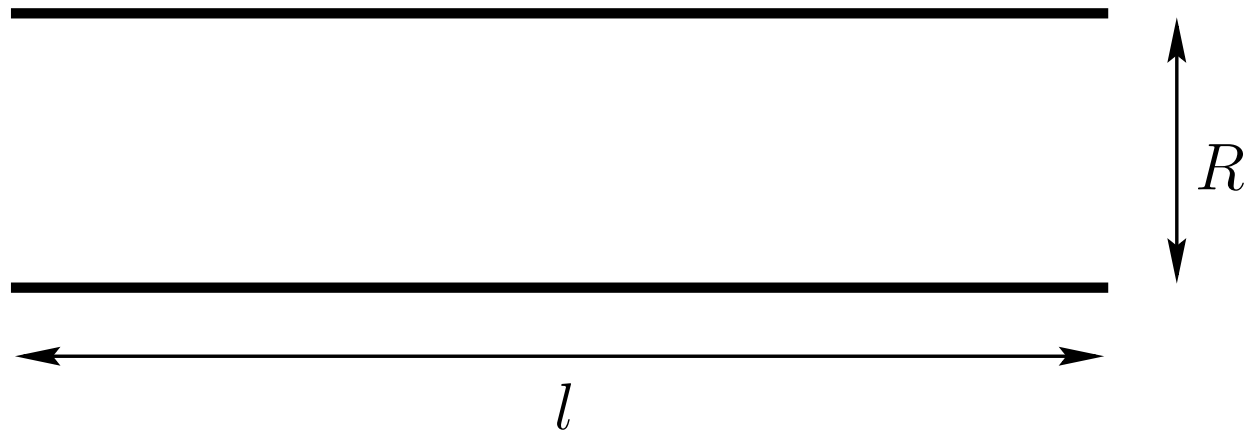
$$\ln(\text{GMD}) = \frac{1}{w^2} \int_{-0.5w}^{0.5w} \int_{-0.5w}^{0.5w} \ln |x_1 + x_2| dx_1 dx_2 = \ln(w) - 1.5$$

$$\text{AMD} = \frac{1}{w^2} \int_{-0.5w}^{0.5w} \int_{-0.5w}^{0.5w} |x_1 + x_2| dx_1 dx_2 = \frac{w}{3}$$

$$\text{AMSD}^2 = \frac{1}{w^2} \int_{-0.5w}^{0.5w} \int_{-0.5w}^{0.5w} |x_1 + x_2|^2 dx_1 dx_2 = \frac{w^2}{6}$$

## PARALLEL LINES OF EQUAL LENGTH

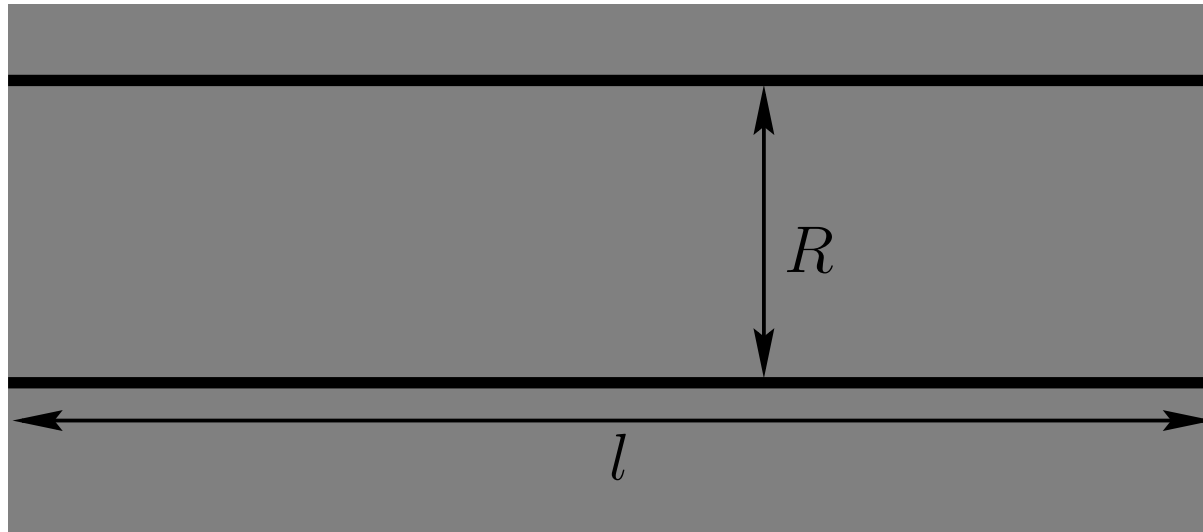
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$$M \approx \frac{\mu l}{2\pi} \left[ \ln(2l) - \ln(R) - 1 + \frac{R}{l} - \frac{R^2}{4l^2} \right] \text{ for } \left( \frac{R}{l} \right) \leq 1$$

# INDUCTANCE OF CURRENT SHEET

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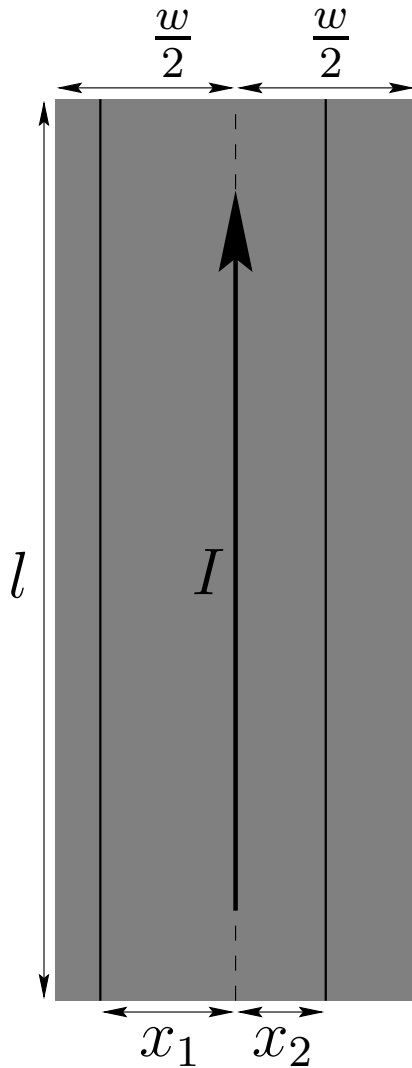


$$M = \frac{\mu l}{2\pi} \left[ \ln(2l) - \ln(R) - 1 + \frac{R}{l} - \frac{R^2}{4l^2} \right]$$

$$L_s = \frac{\mu l}{2\pi} \left[ \ln(2l) - \ln(\text{GMD}) - 1 + \frac{\text{AMD}}{l} - \frac{\text{AMSD}^2}{4l^2} \right]$$

# INDUCTANCE OF RECTANGULAR CURRENT SHEET

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$$-\frac{w}{2} < x_1, x_2 < \frac{w}{2}$$

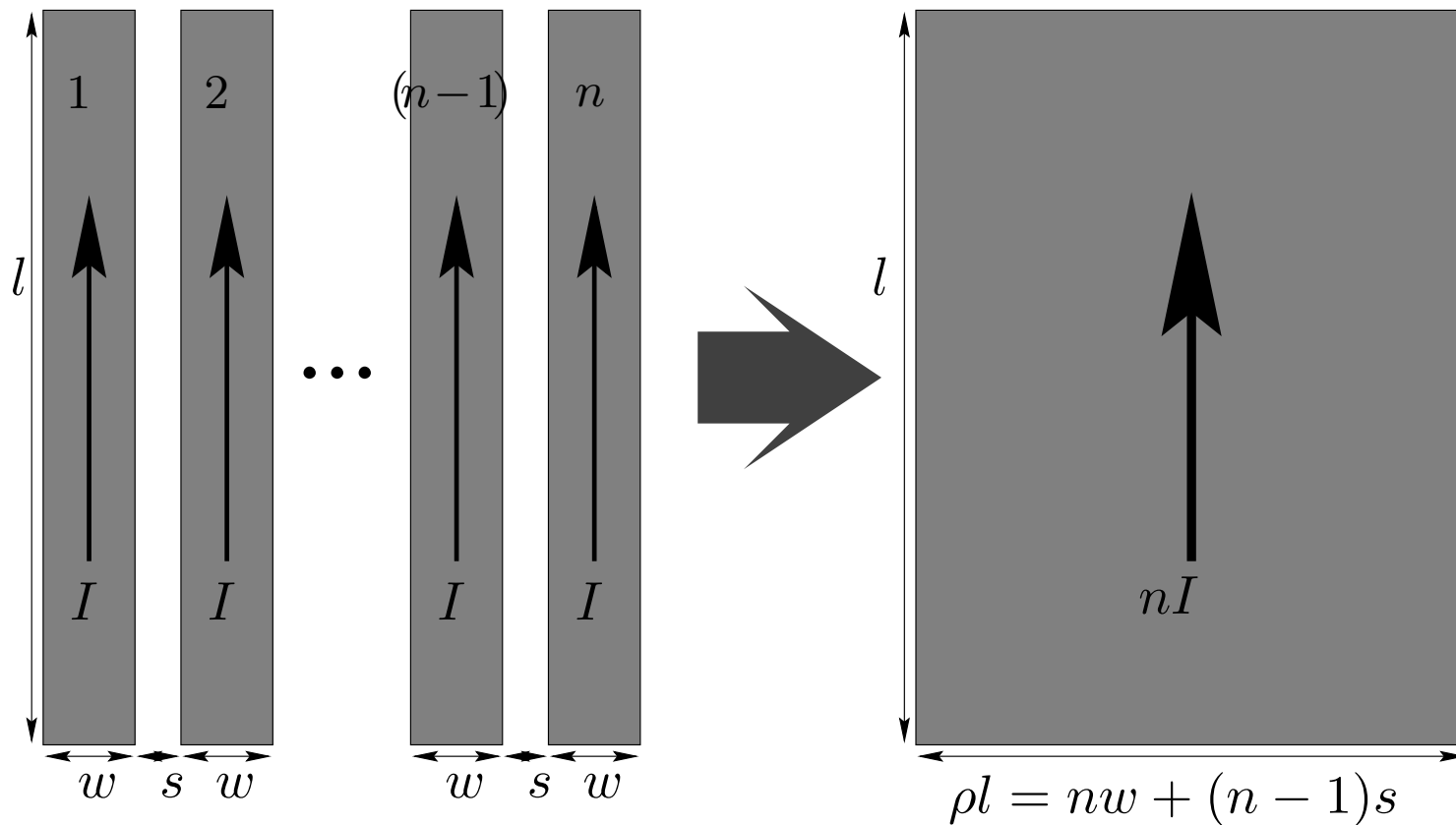
$$\ln(\text{GMD}) = \overline{\ln |x_1 + x_2|} = \ln w - 1.5$$

$$\text{AMD} = \overline{|x_1 + x_2|} = \frac{w}{3}$$

$$\text{AMSD}^2 = \overline{(x_1 + x_2)^2} = \frac{w^2}{6}$$

$$L = \frac{\mu l}{2\pi} \left[ \ln \left( \frac{2l}{w} \right) + 0.5 + \frac{w}{3l} - \frac{w^2}{24l^2} \right]$$

# EQUIVALENT RECTANGULAR CURRENT SHEET

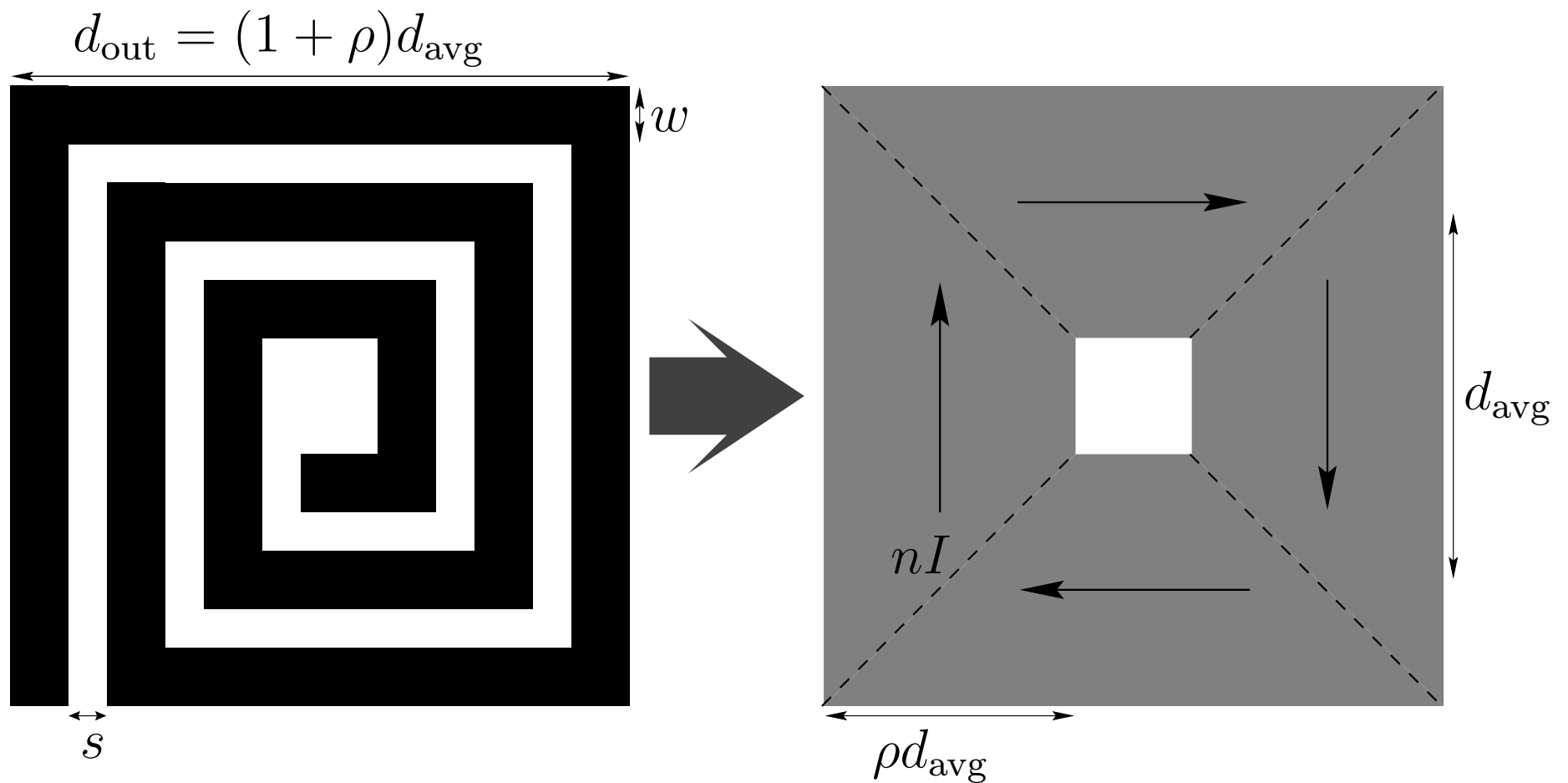


$$L = \frac{\mu n^2 l}{2\pi} \left[ \ln \left( \frac{2}{\rho} \right) + 0.5 + \frac{\rho}{3} - \frac{\rho^2}{24} \right]$$



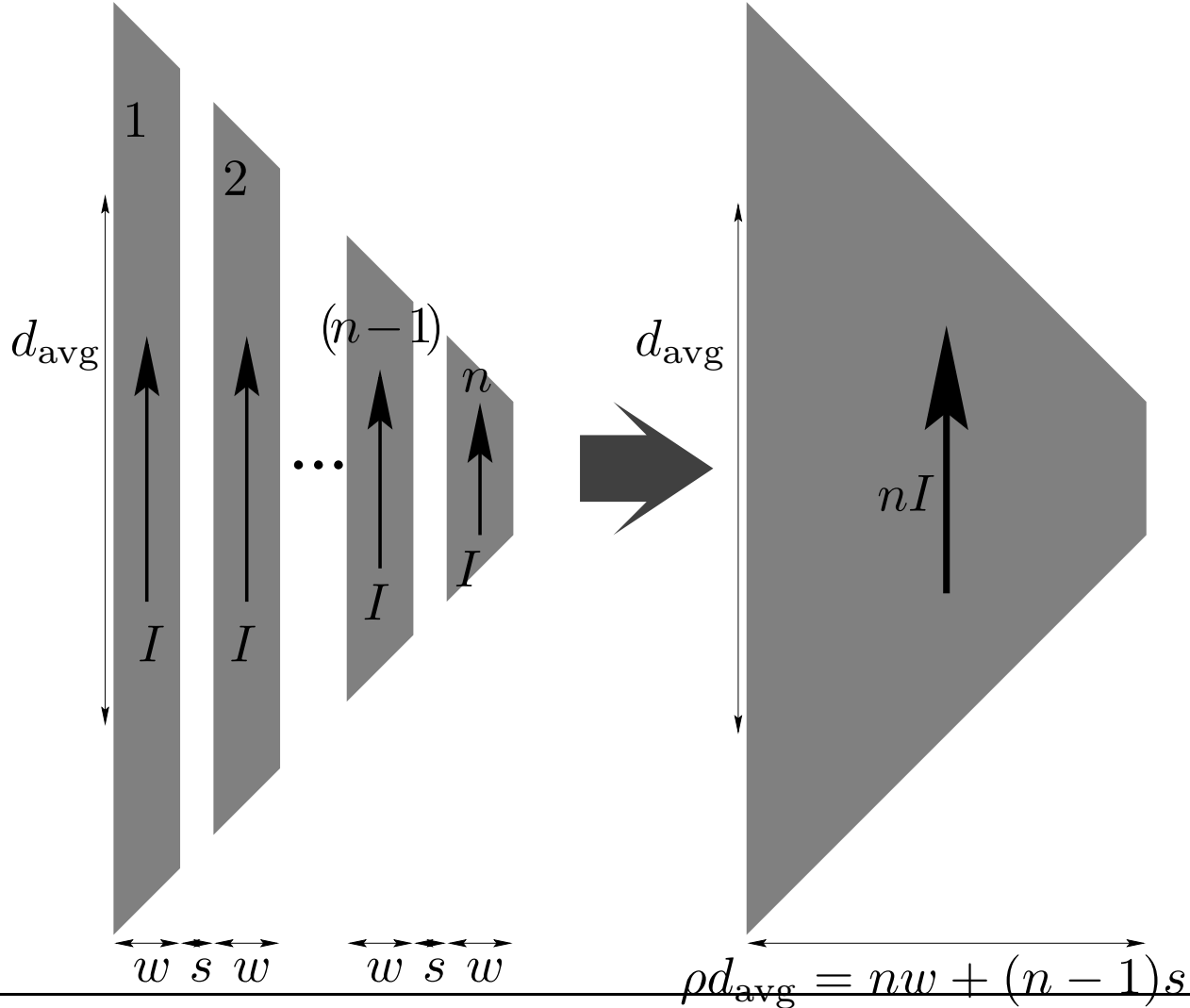
# APPROXIMATING A SQUARE SPIRAL

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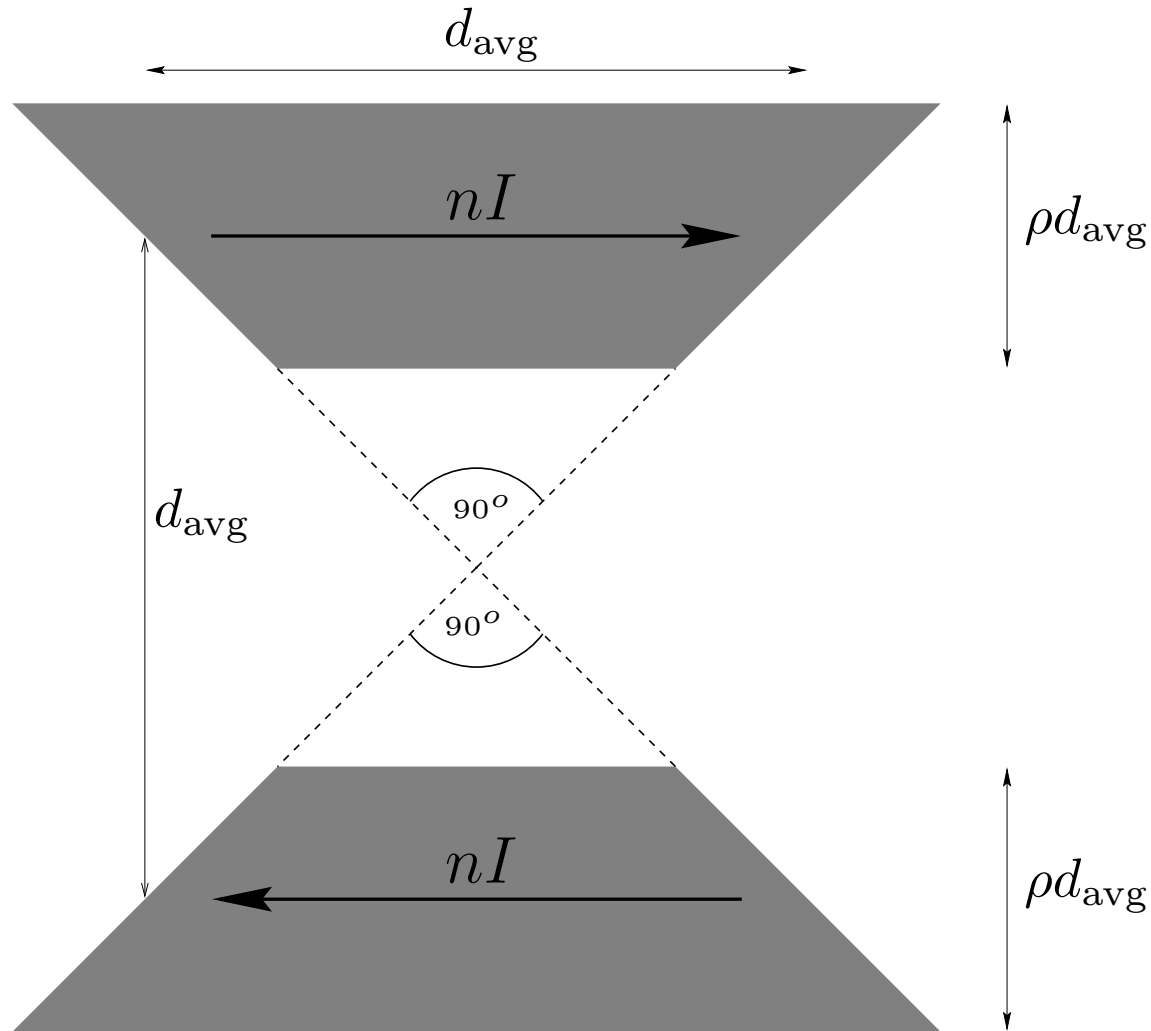
# ONE SIDE OF A SQUARE SPIRAL: $L_S$

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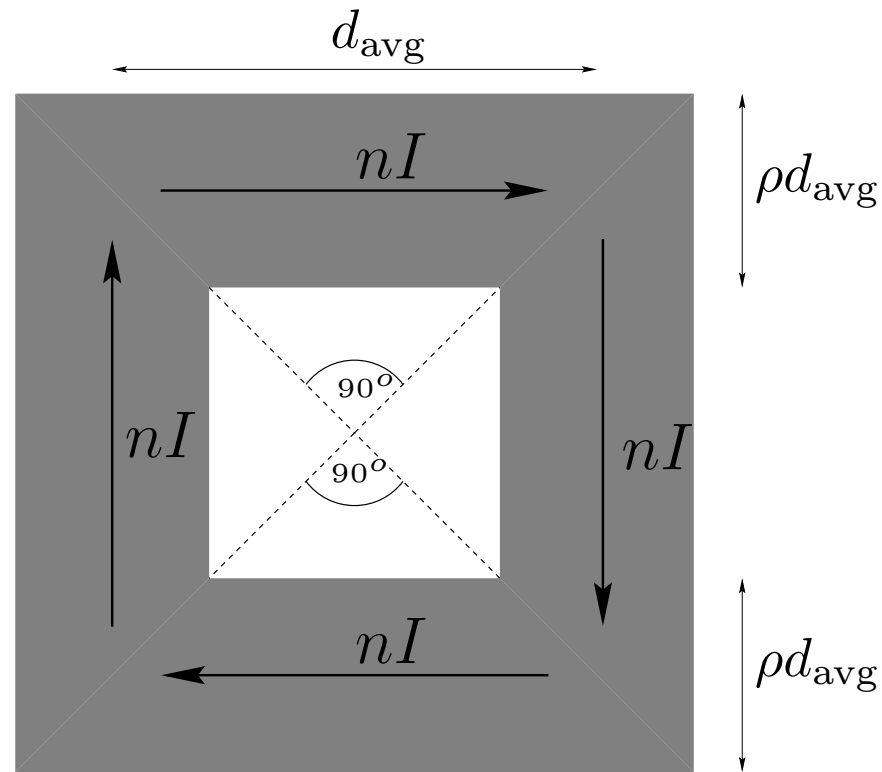


# OPPOSITE SIDES OF A SQUARE SPIRAL: $M_{\text{opp}}$

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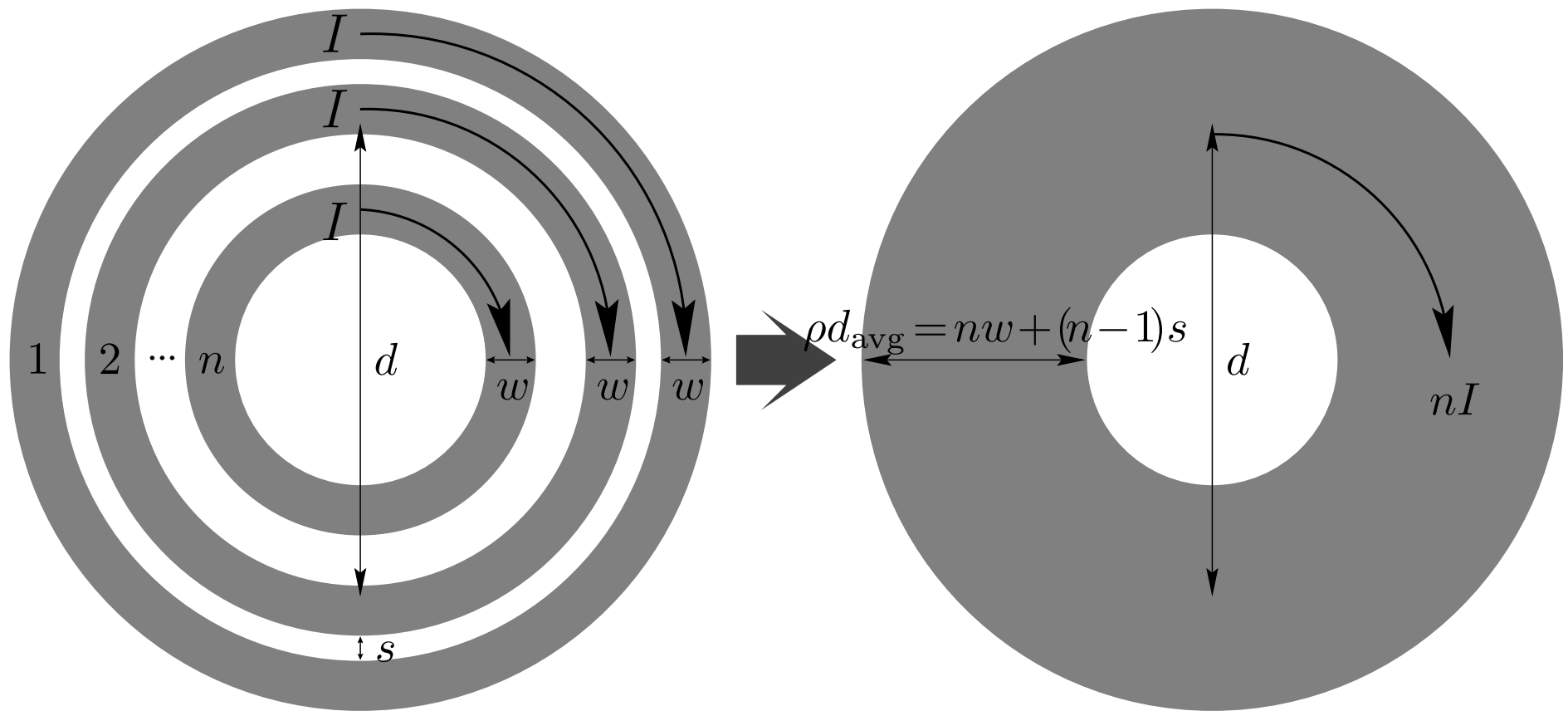


# CURRENT SHEET EXPRESSION FOR A SQUARE SPIRAL



$$\begin{aligned} L_{\text{sq}} &= 4(L_s + M_{\text{opp}}) \\ &= \frac{2\mu n^2 d_{\text{avg}}}{\pi} \left[ \ln \left( \frac{2.067}{\rho} \right) + 0.178\rho + 0.125\rho^2 \right] \end{aligned}$$

# CONCENTRIC CIRCULAR CONDUCTORS



$$L \approx \frac{\mu n^2 d_{\text{avg}}}{2} \left[ \ln \left( \frac{1}{\rho} \right) + 0.9 + 0.2\rho^2 \right]$$

# CURRENT SHEET EXPRESSIONS

$$L_{\text{cursh}} = \frac{\mu n^2 d_{\text{avg}} c_1}{2} [\ln(c_2/\rho) + c_3\rho + c_4\rho^2]$$

<b>Layout</b>	$c_1$	$c_2$	$c_3$	$c_4$
<b>Square</b>	1.27	2.07	0.18	0.13
<b>Hexagonal</b>	1.09	2.23	0.00	0.17
<b>Octagonal</b>	1.07	2.29	0.00	0.19
<b>Circle</b>	1.00	2.46	0.00	0.20

## OTHER INDUCTANCE EXPRESSIONS

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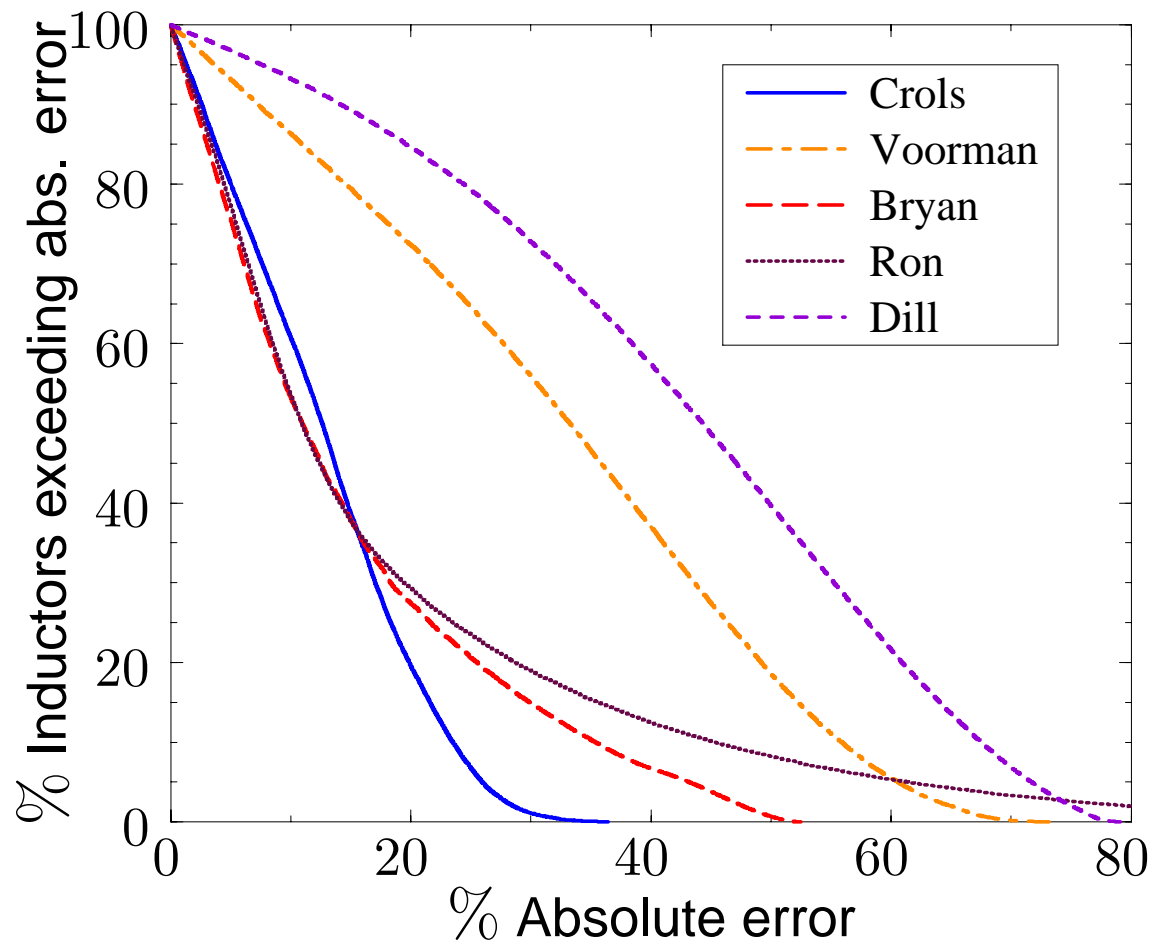
- Monomial Expression :

$$L_{\text{mon}} = \beta d_{\text{out}}^{\alpha_1} w^{\alpha_2} d_{\text{avg}}^{\alpha_3} n^{\alpha_4} s^{\alpha_5}$$

- Modified Wheeler Expression :

$$L_{\text{mw}} = K_1 \mu_0 \frac{n^2 d_{\text{avg}}}{1 + K_2 \rho}$$

# COMPARISON TO FIELD SOLVERS: PREVIOUS WORK



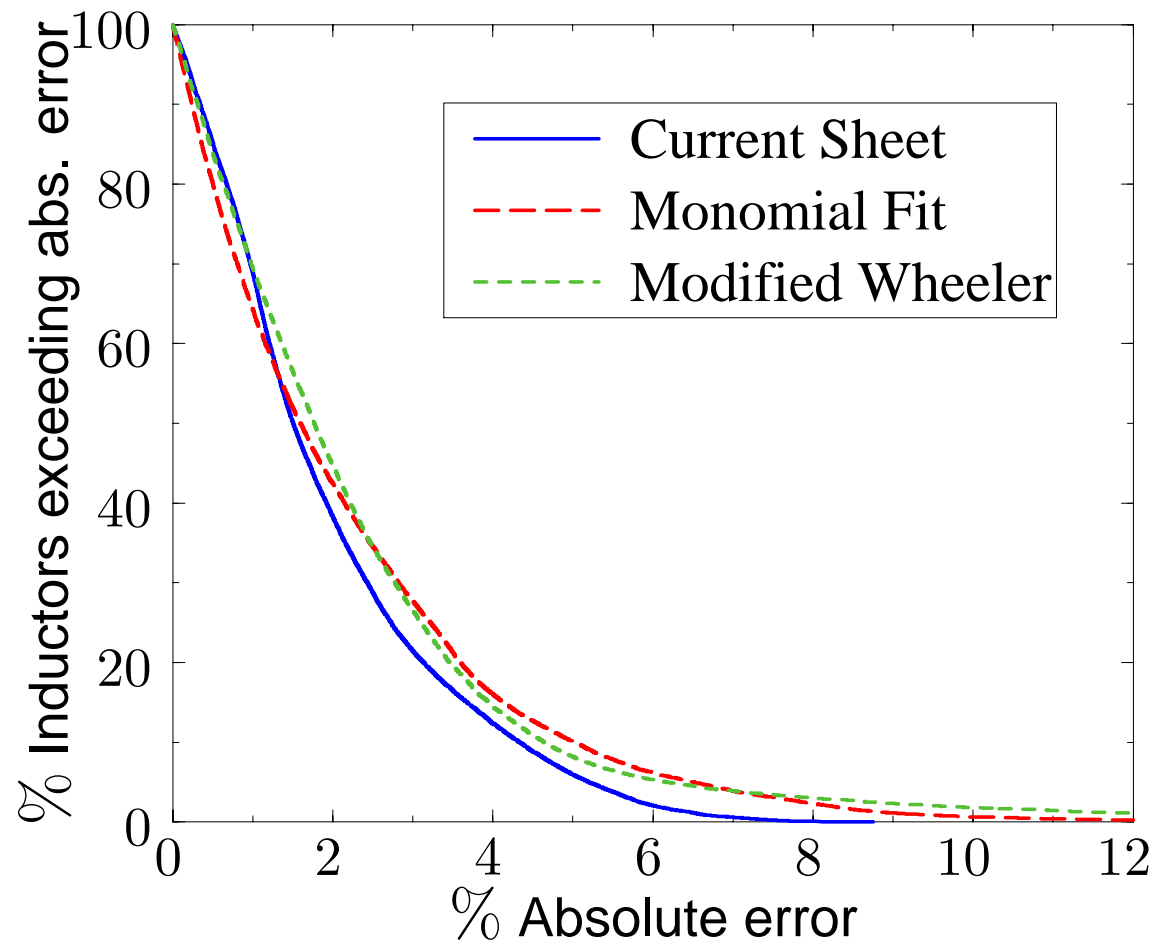
	<b>Min</b>	<b>Max</b>
$L(\text{nH})$	0.1	70
$OD(\mu\text{m})$	100	400
$n$	1	20
$s/w$	0.02	3
$\rho$	0.03	0.95

19,000 simulations



# COMPARISON TO FIELD SOLVERS: NEW WORK

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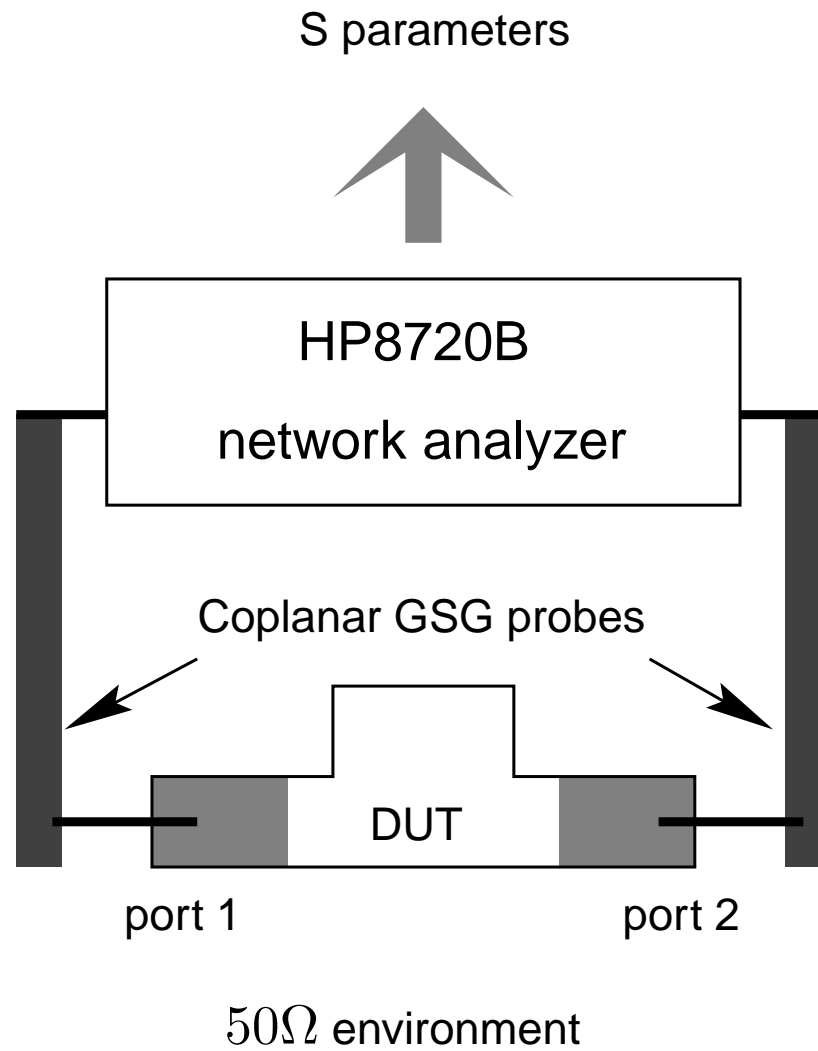


	<b>Min</b>	<b>Max</b>
$L$ (nH)	0.1	70
OD( $\mu\text{m}$ )	100	400
$n$	1	20
$s/w$	0.02	3
$\rho$	0.03	0.95

19,000 simulations

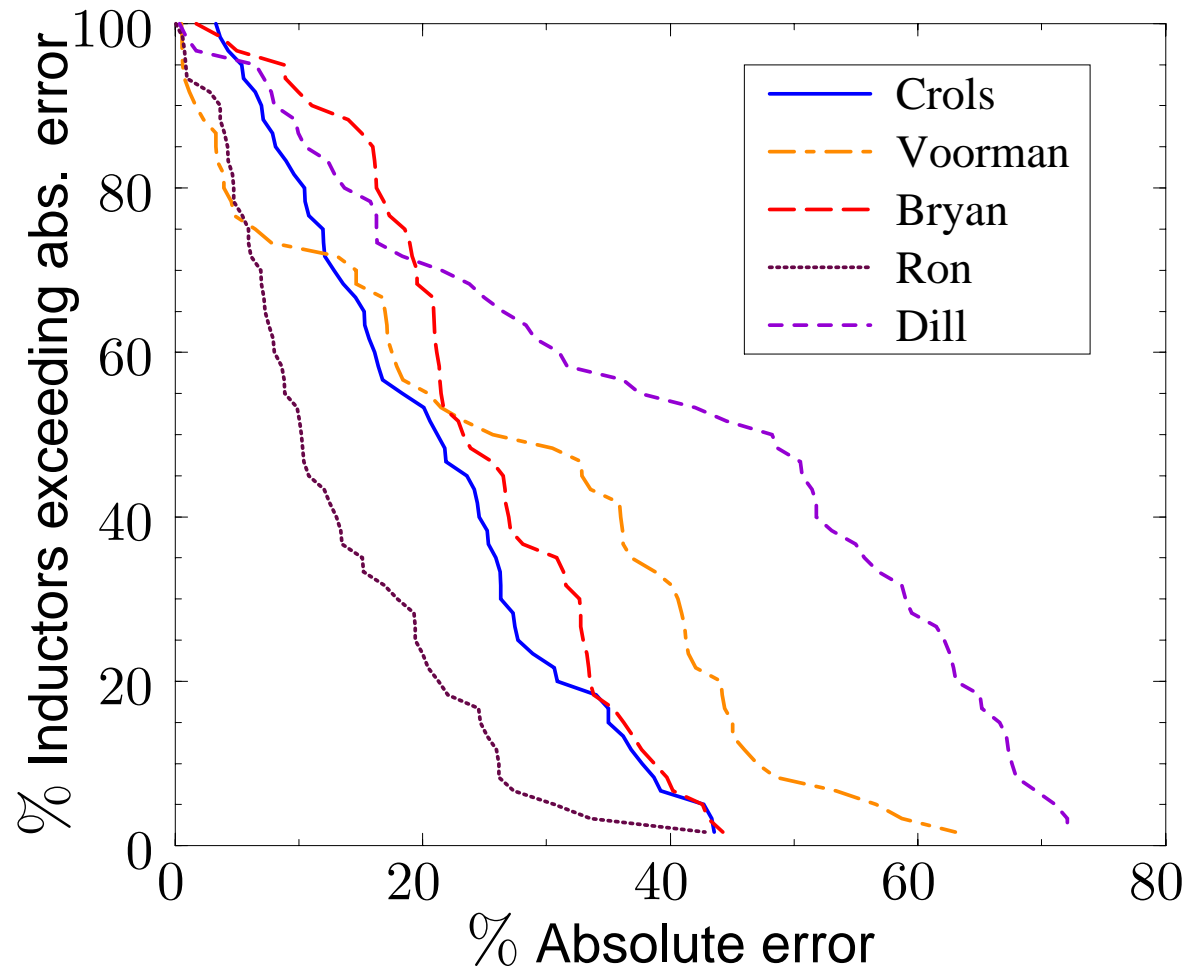
# EXPERIMENTAL SET-UP

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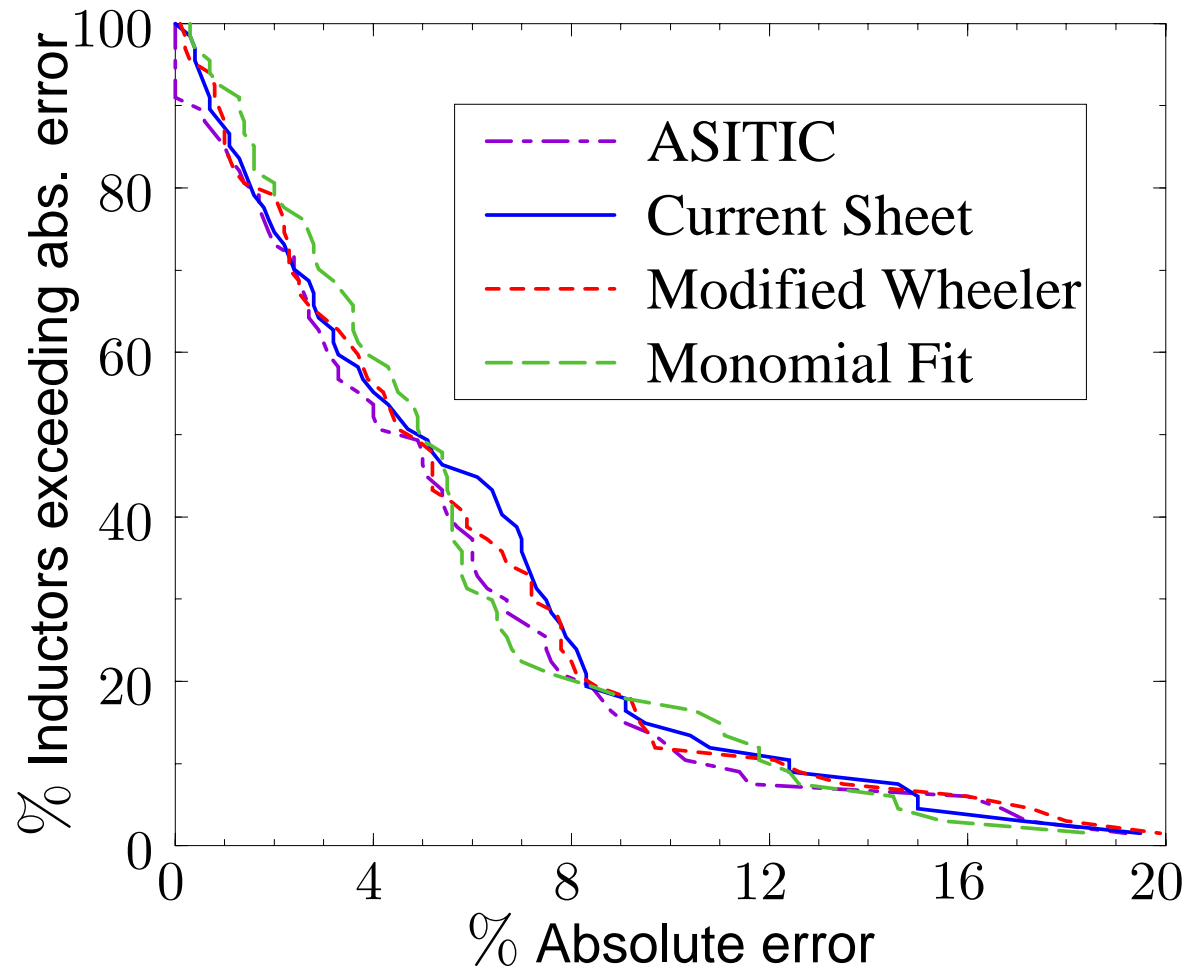
# COMPARISON TO EXPERIMENTS: PREVIOUS WORK

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# COMPARISON TO EXPERIMENTS: NEW WORK

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# PARAMETERS OF INTEREST

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- Inductor quality factor ( $Q_L$ )

$$Q_L = 2\pi \frac{[\text{peak magnetic energy} - \text{peak electric energy}]}{\text{energy loss in one oscillation cycle}}$$

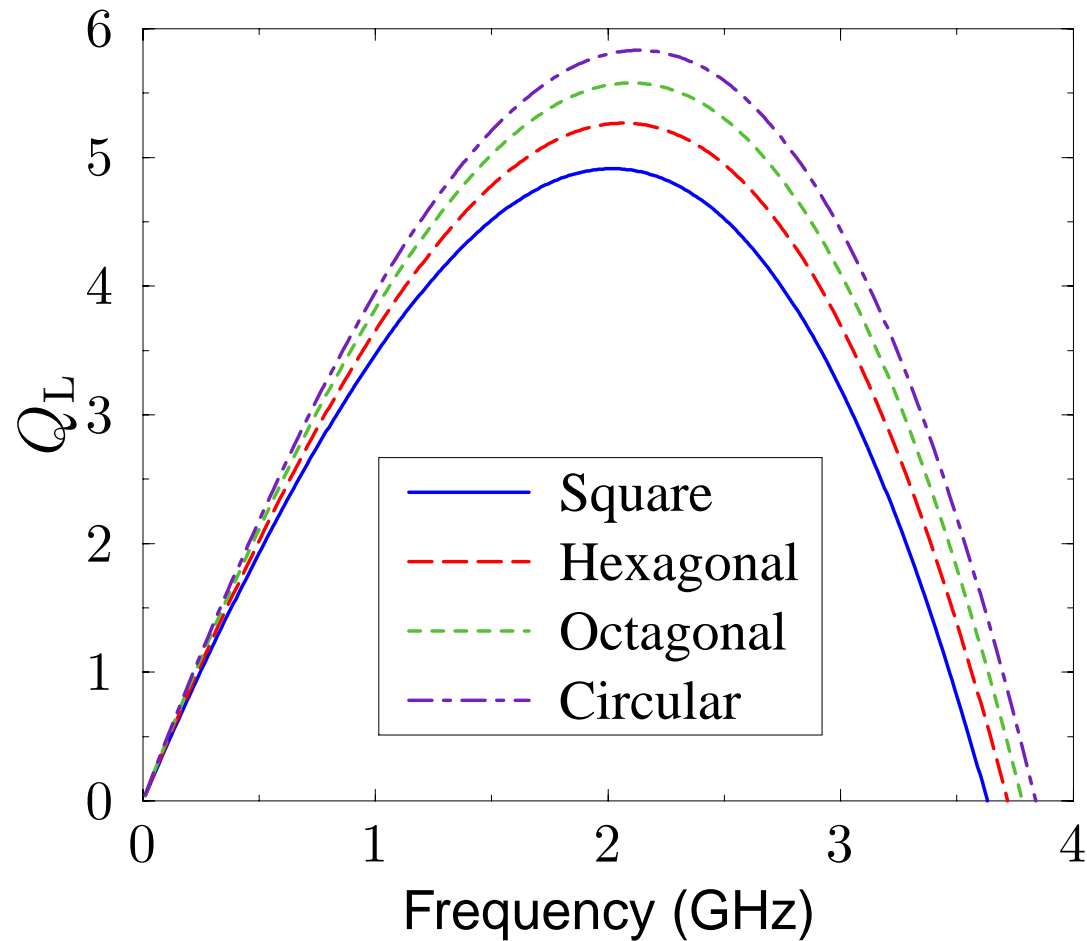
- Tank quality factor ( $Q_{\text{tank}}$ )

$$Q_{\text{tank}} = 2\pi \frac{\text{peak magnetic energy}}{\text{energy loss in one oscillation cycle}}$$

- Self-resonance frequency ( $\omega_{\text{res}}$ ), frequency at which  $Q_L = 0$

# EXAMPLE: MAXIMUM $Q_L$ @ 2GHz FOR $L = 8\text{nH}$

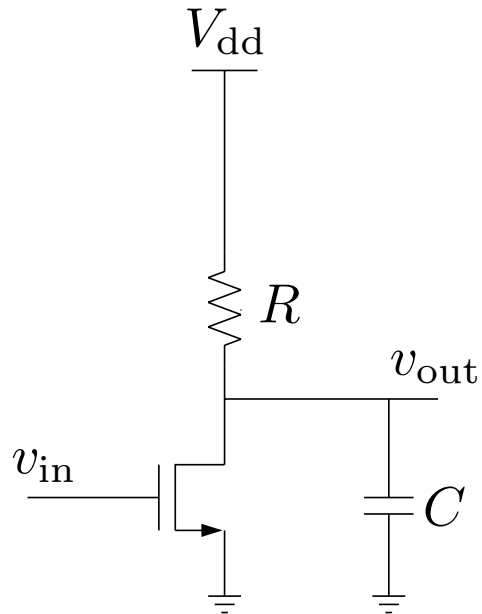
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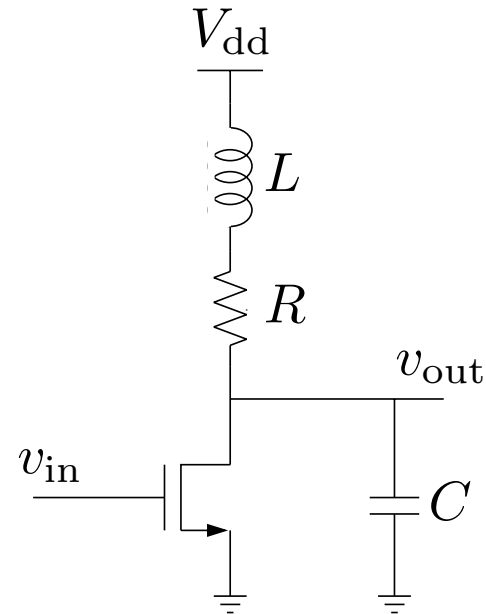
# EXAMPLE: SHUNT-PEAKED AMPLIFIER

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Common Source Amplifier



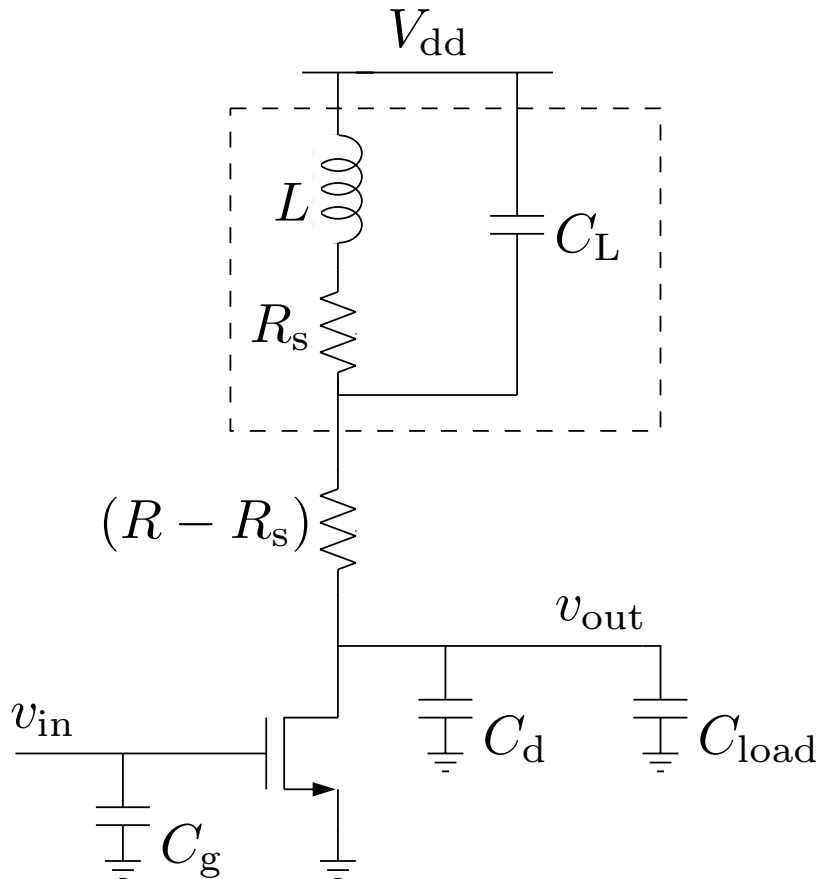
Shunt-peaked Amplifier



- Bandwidth enhancement using zeros
- No additional power dissipation

# ON-CHIP SHUNT PEAKING

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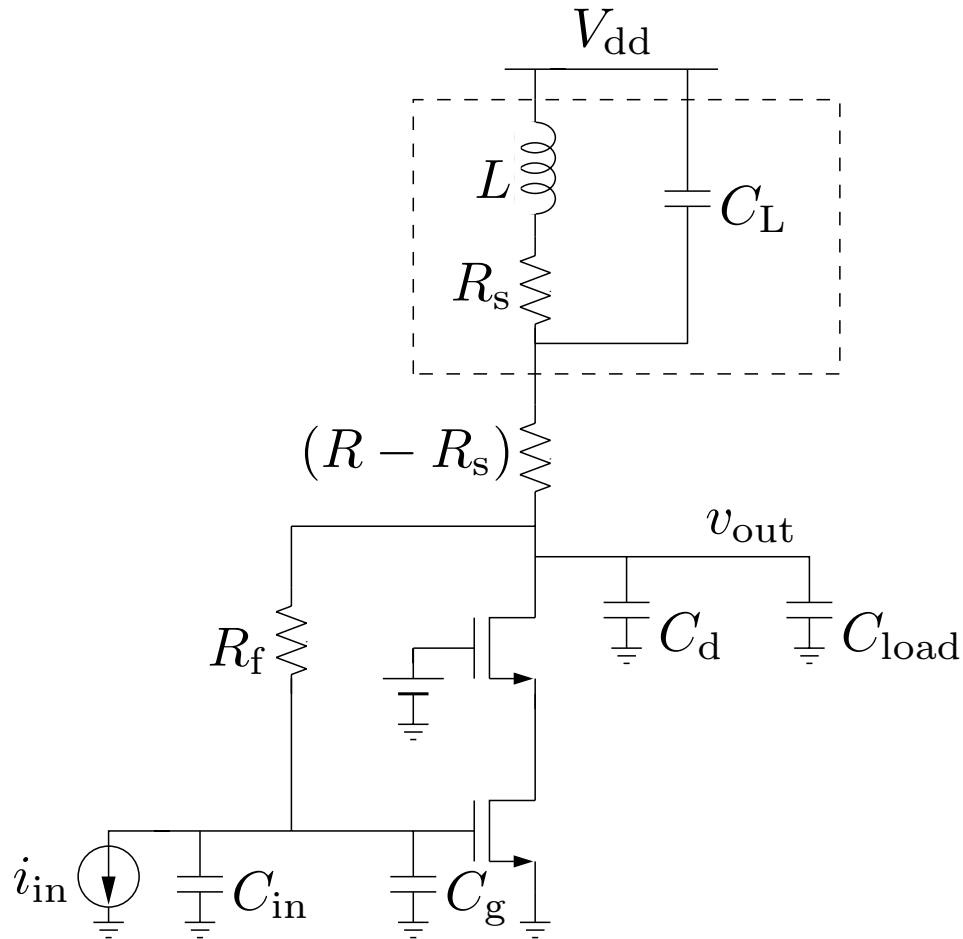


- Work with inductor parasitics
- $R_s$  is **not** an issue  
(now part of load resistance)
- Inductor Q is **not** relevant
- Minimize area and  $C_L$
- $L$  determined by  
 $R$ ,  $C_{load}$ ,  $C_L$  and  $C_d$



# SHUNT-PEAKED TRANSIMPEDANCE AMPLIFIER

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- Input current drive
- Cascode stage
- On-chip shunt-peaking
- Feedback

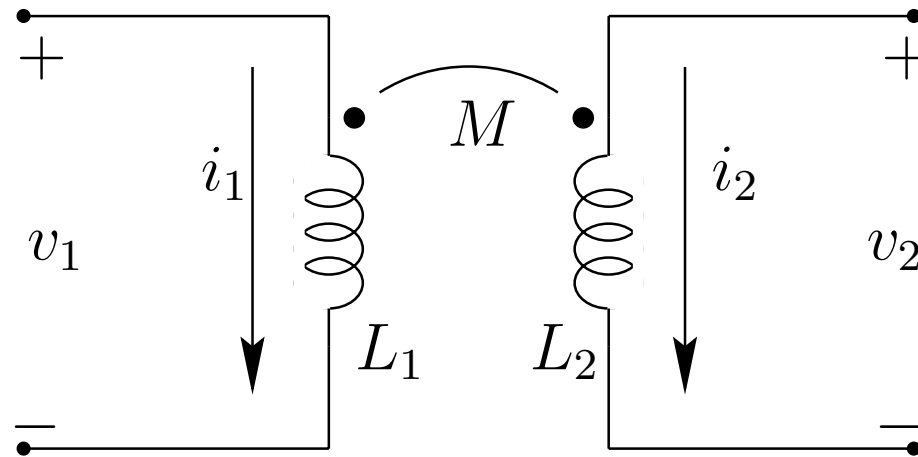
## DESIGN METHODOLOGY

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1. Design and optimize transimpedance stage without shunt peaking
2. Transistor current determines conductor width,  $w$
3. Lithography sets spacing,  $s$
4. Choose  $n$  and  $AD$  to realize desired  $L$  while minimizing parasitic capacitance and area
5. Maximize transimpedance resistance,  $R_f$

# TRANSFORMER

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- $v_1 = L_1 \frac{\partial i_1}{\partial t} + M \frac{\partial i_2}{\partial t}$

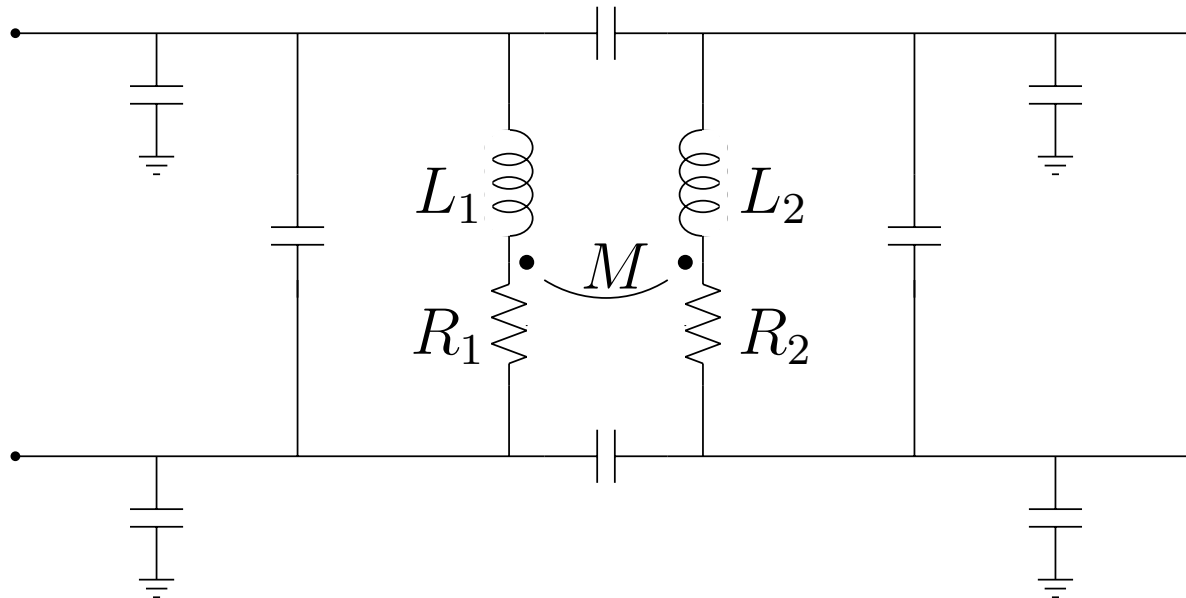
- $v_2 = L_2 \frac{\partial i_2}{\partial t} + M \frac{\partial i_1}{\partial t}$

- Mutual coupling coefficient,  $k = \frac{M}{\sqrt{L_1 L_2}}$

- $|k| \leq 1$

# NON-IDEAL TRANSFORMER

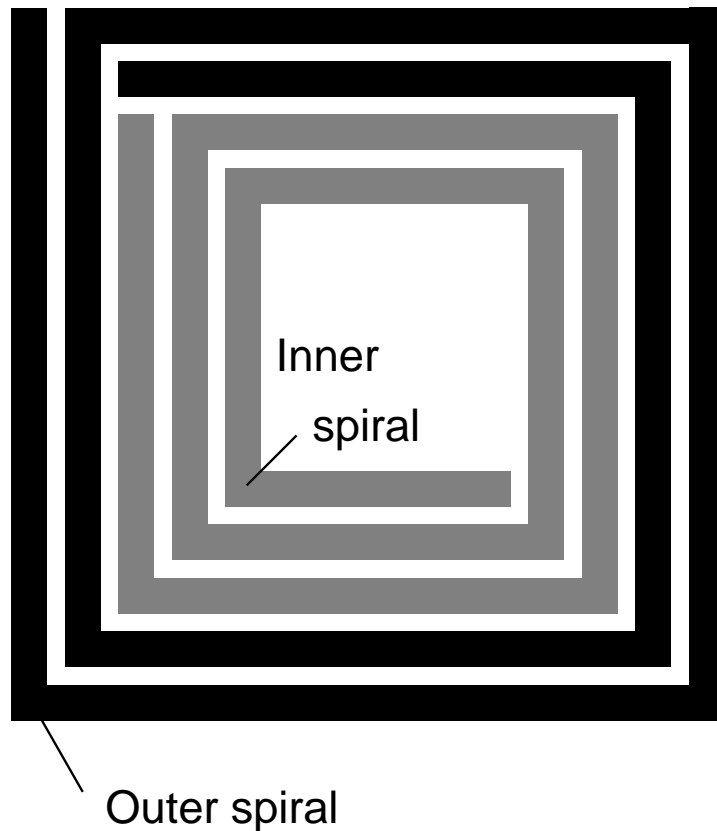
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- $k = \frac{M}{\sqrt{L_1 L_2}} < 1.$
- Series resistance.
- Port-to-port & port-to-substrate capacitances

# TAPPED TRANSFORMER

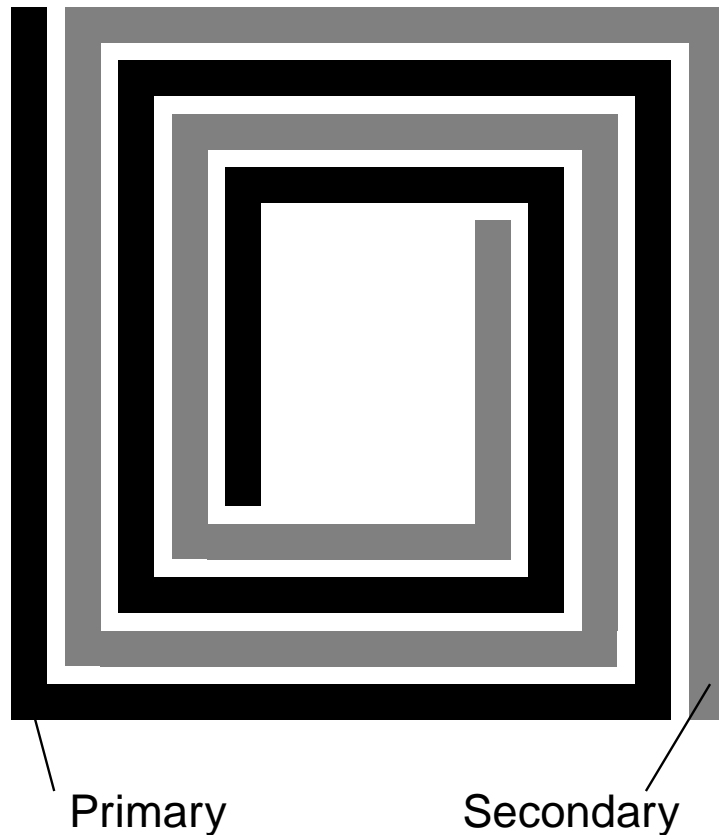
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- **advantages:**
  - { High  $L_1, L_2$
  - { Top metal layer
  - { Low port-to-port capacitance
- **disadvantages:**
  - { Asymmetric
  - { Low  $k$  ( $\approx 0.3 - 0.5$ )

# INTERLEAVED TRANSFORMER

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- **advantages:**

- { Medium  $k$   
( $\approx 0.7 - 0.8$ )

- { Symmetric

- { Top metal layer

- **disadvantages:**

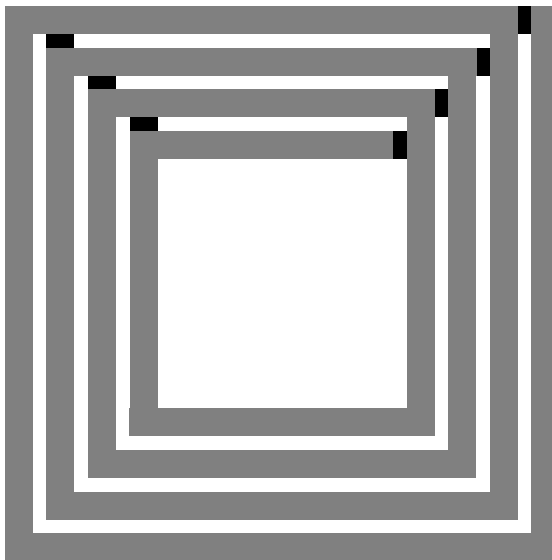
- { Medium port-to-port  
capacitance

- { Low  $L_1, L_2$

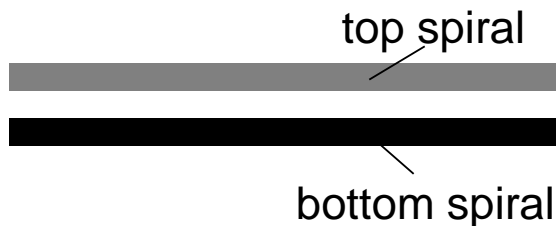
# STACKED TRANSFORMER

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Top View



Side View



- **advantages:**

- { High  $k (\approx 0.9)$

- { High  $L_1, L_2$

- { Area efficient

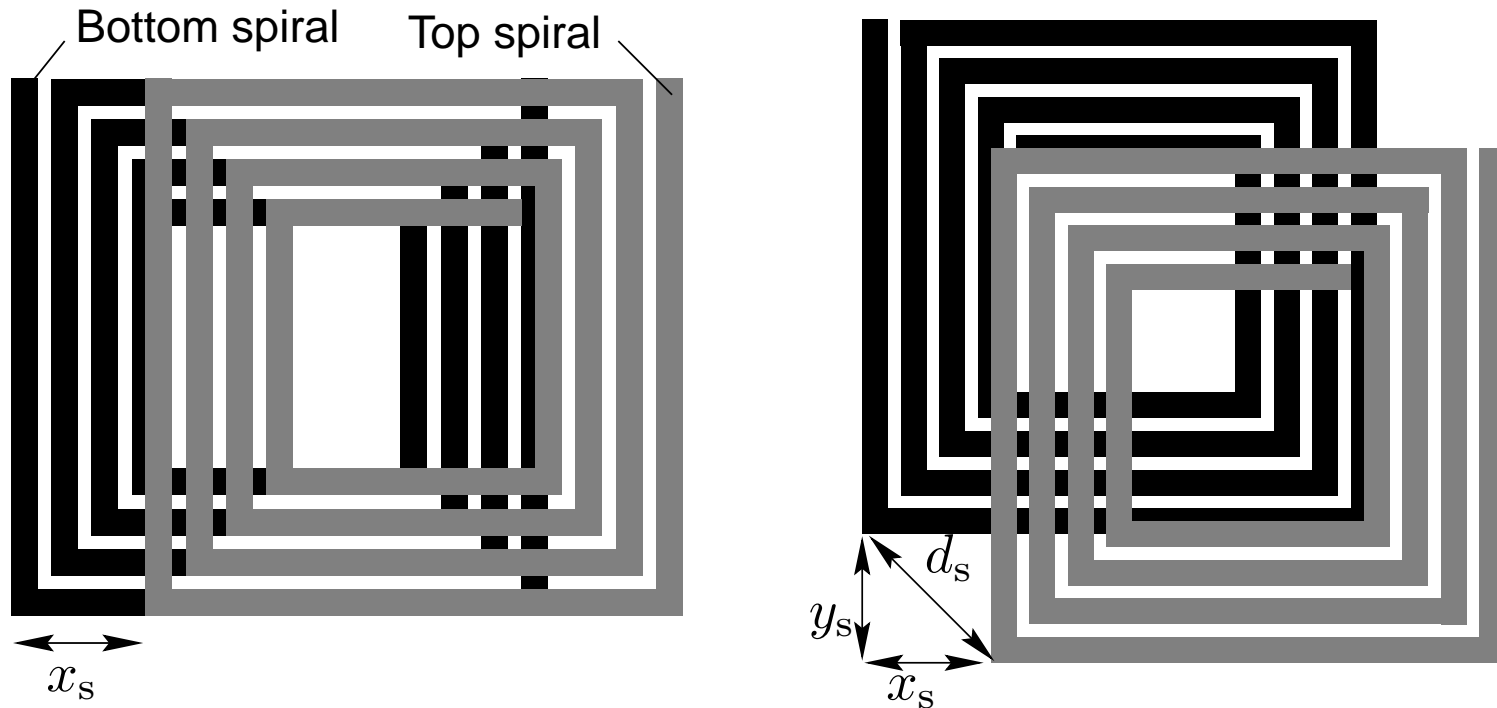
- **disadvantages:**

- { Multiple metal layers

- { High port-to-port & port-to-substrate capacitances

# STACKED TRANSFORMER VARIATIONS

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- Shift top and bottom spirals laterally or diagonally
- Trade-off lower  $k$  for reduced port-to-port capacitance



# COMPARISON OF TRANSFORMER REALIZATIONS

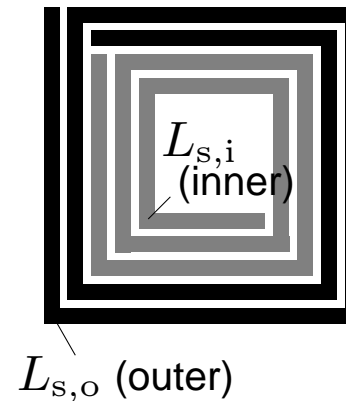
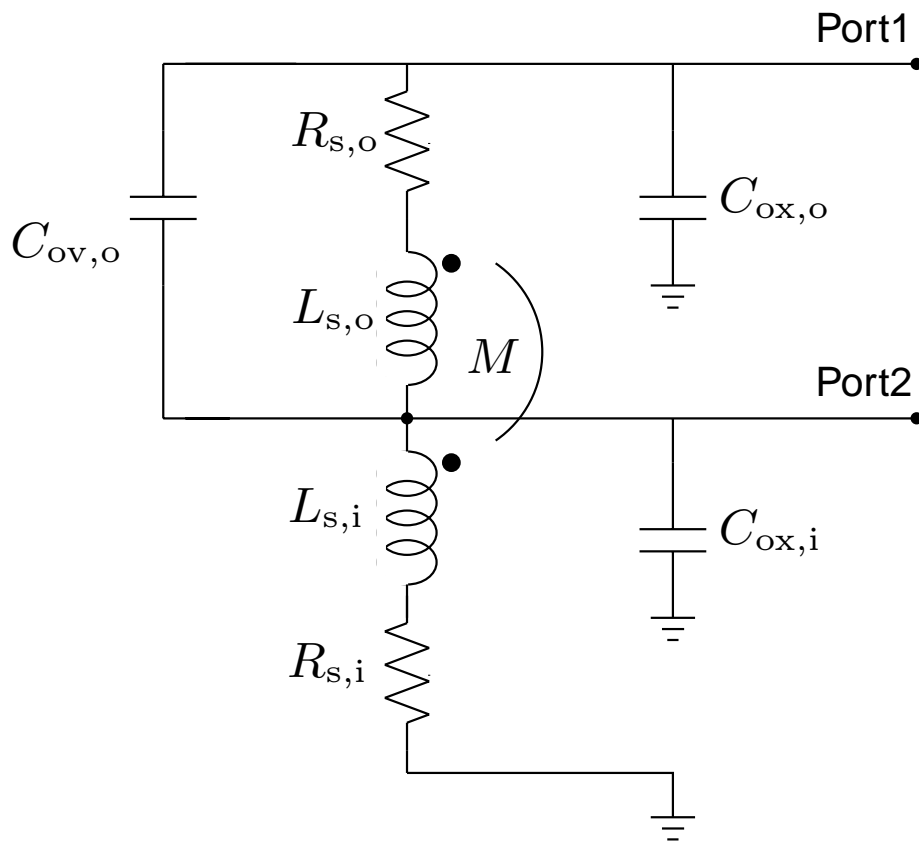
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<b>Transformer type</b>	<b>Area</b>	<b>Coupling coefficient, <math>k</math></b>	<b>Self-inductance</b>	<b>Self-resonant frequency</b>
<b>Tapped</b>	High	Low	Mid	High
<b>Interleaved</b>	High	Mid	Low	High
<b>Stacked</b>	Low	High	High	Low

- Non-idealities result in trade-offs
- Optimal choice determined by circuit application
- Transformer **models** needed for comparison

# TAPPED TRANSFORMER MODEL

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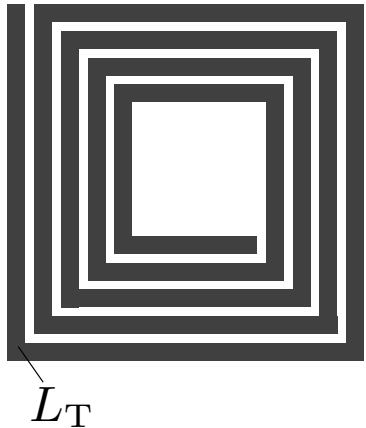


- Evaluate  $C_{ov,o}$ ,  $C_{ox,o}$ ,  $C_{ox,i}$ ,  $R_{s,o}$  &  $R_{s,i}$  by extending previous work
- Use inductance expression for  $L_{s,o}$ ,  $L_{s,i}$
- Calculate  $M$

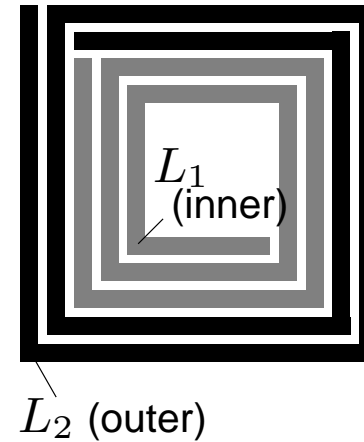
# MUTUAL INDUCTANCE CALCULATION

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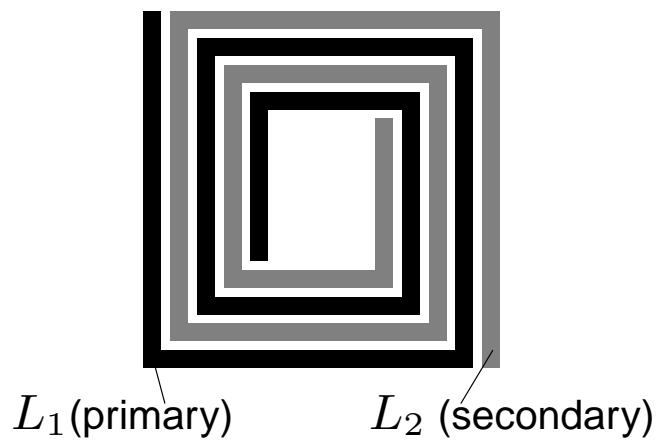
Single inductor.



Tapped transformer.



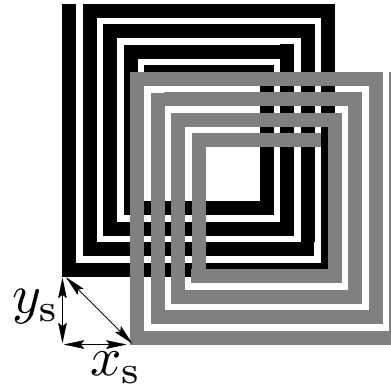
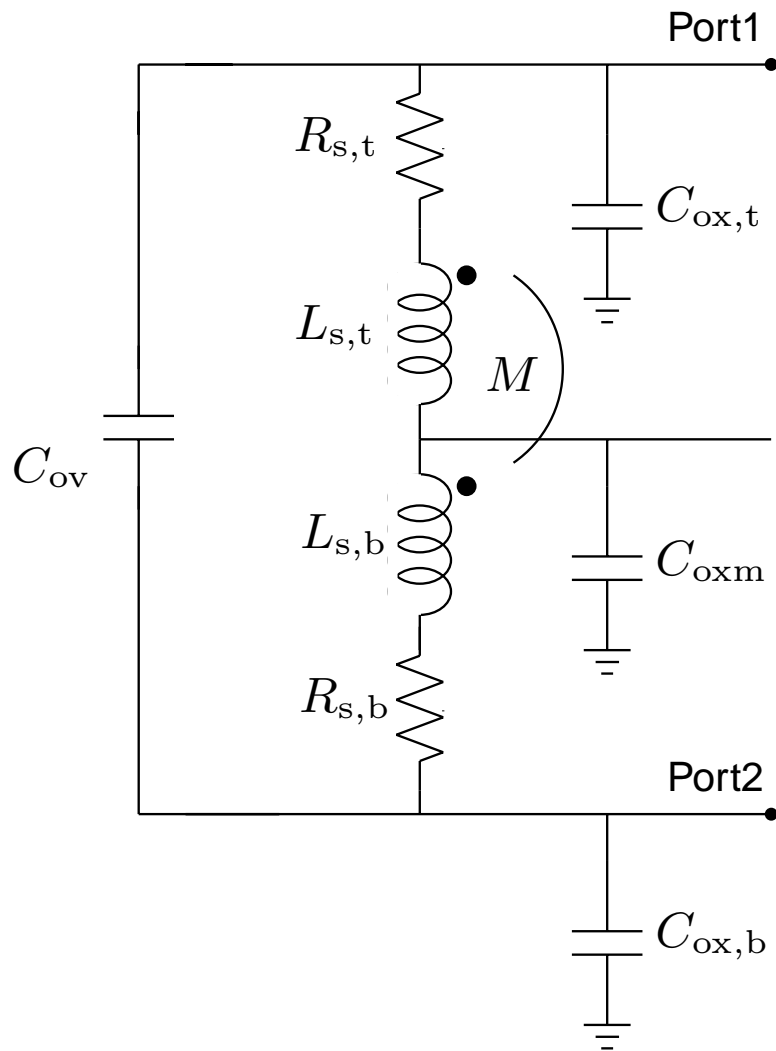
Interleaved transformer.



- $L_T = L_1 + L_2 + 2M$

# STACKED TRANSFORMER MODEL

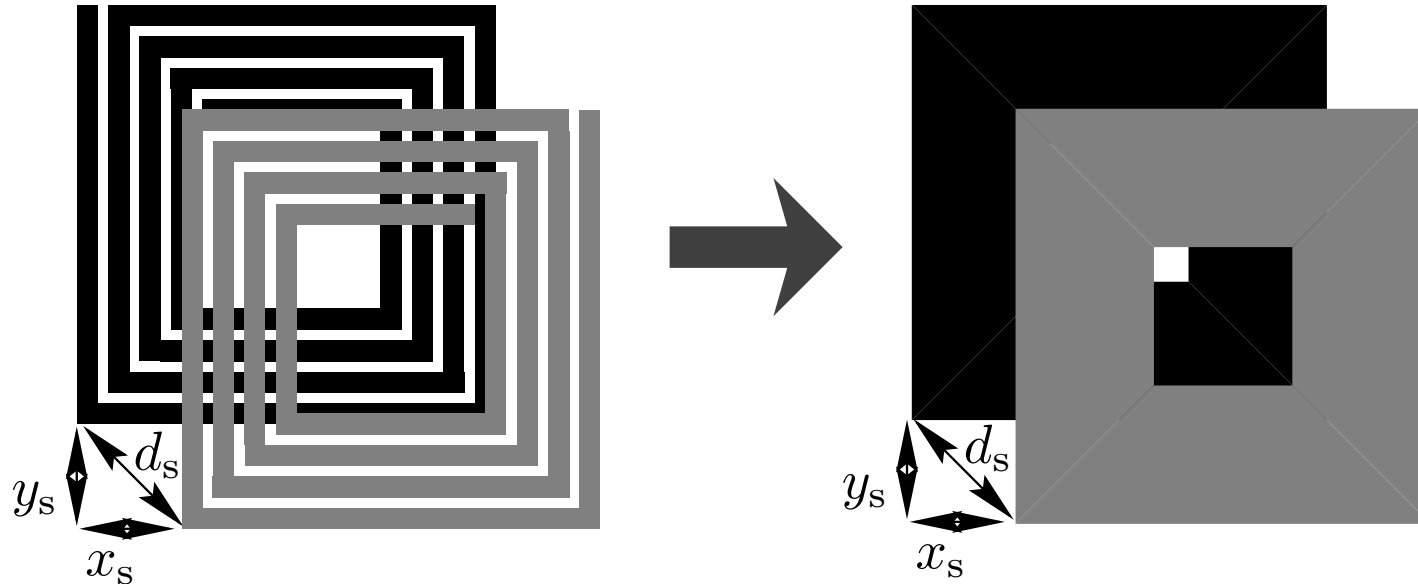
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- Evaluate  $C_{ov}$ ,  $C_{ox,t}$ ,  $C_{oxm}$ ,  $C_{ox,b}$ ,  $R_{s,t}$  &  $R_{s,b}$  by extending previous work
- Use inductance expression for  $L_{s,t}$ ,  $L_{s,b}$
- Calculate  $M$

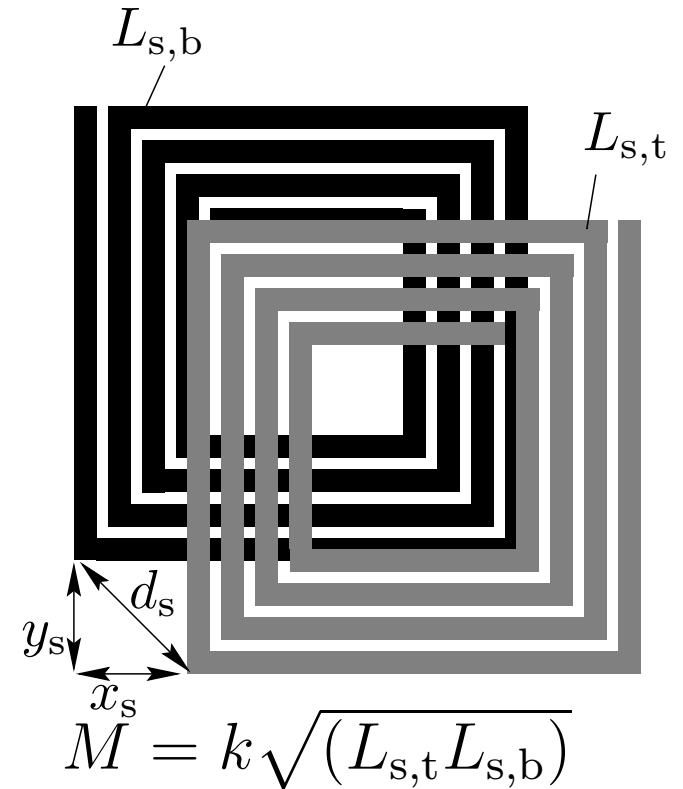
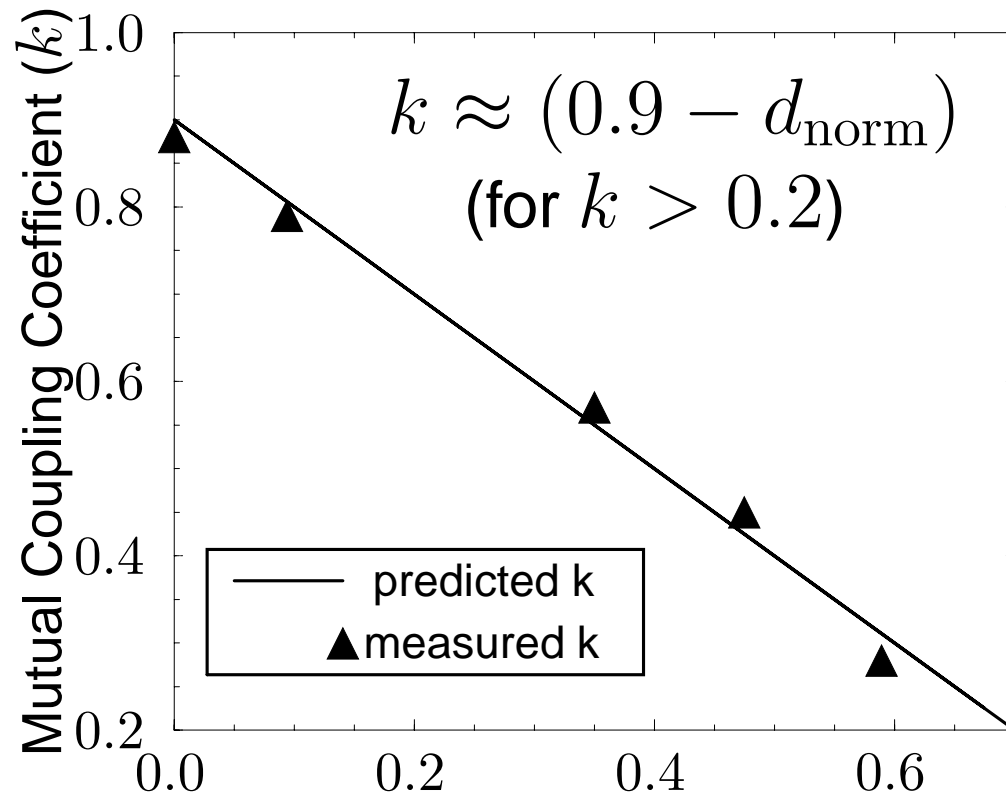
# CURRENT SHEET APPROACH FOR $k$

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- Reduce complexity by  $4n^2$
- Use symmetry
- Derive simple expression using electromagnetic theory

# $k$ FOR STACKED TRANSFORMERS

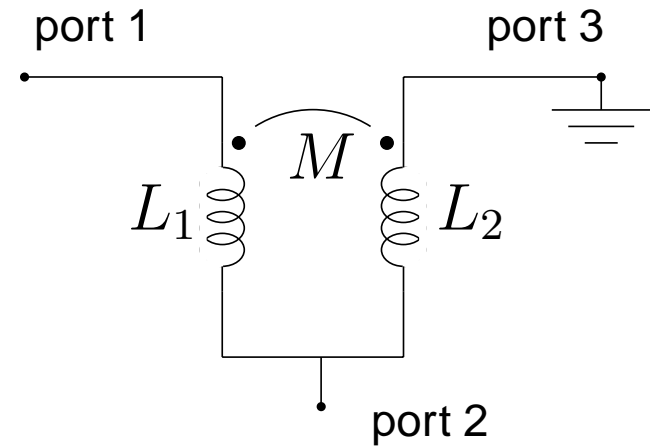
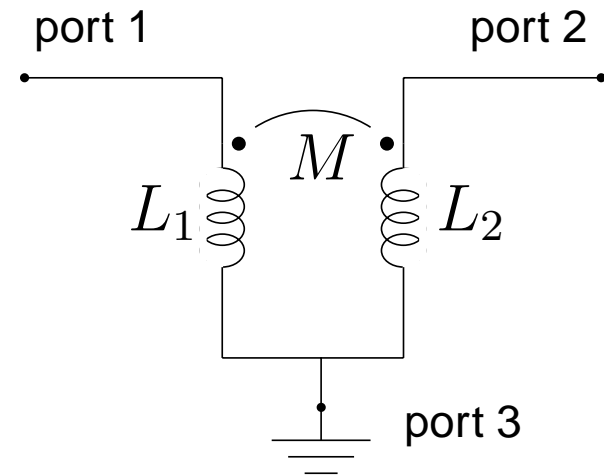
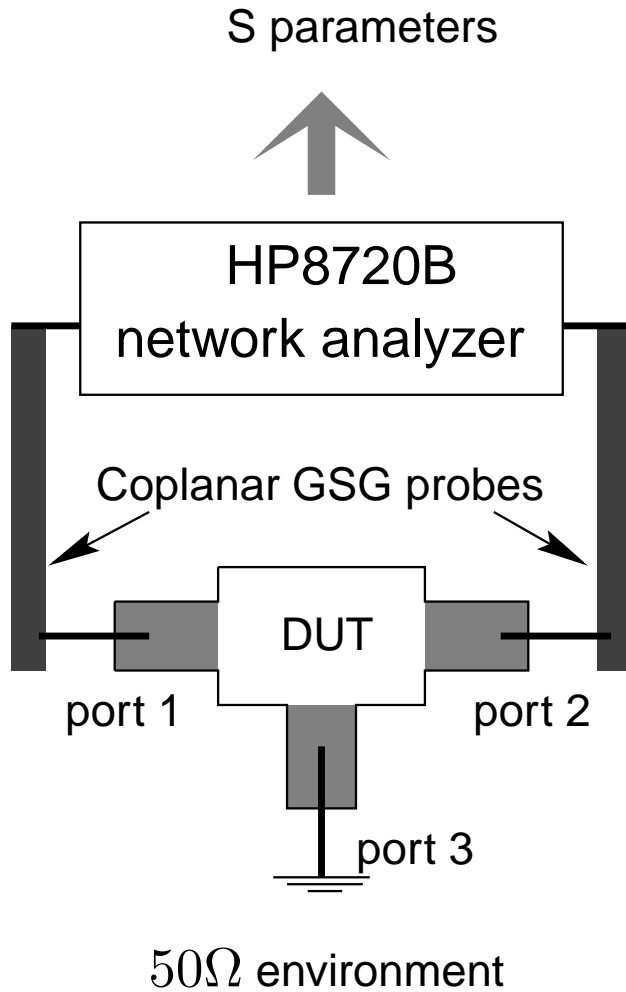


$$d_{\text{norm}} = \frac{\sqrt{x_s^2 + y_s^2}}{AD} = \frac{d_s}{AD}$$

- Metal and oxide thicknesses have only 2nd order effects on  $k$

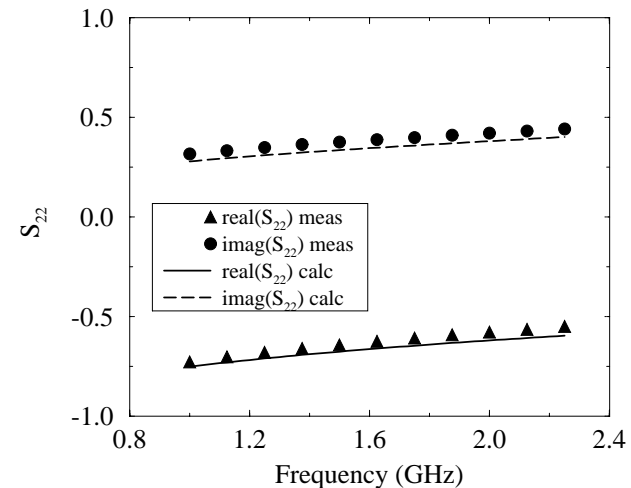
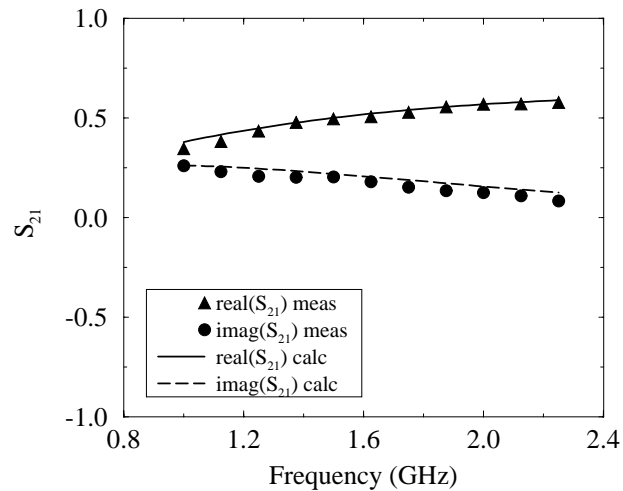
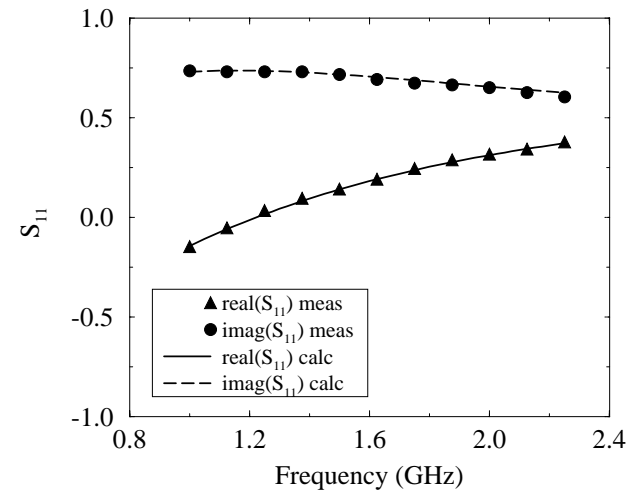
# EXPERIMENTAL SET-UP

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# EXPERIMENTAL VERIFICATION: TAPPED

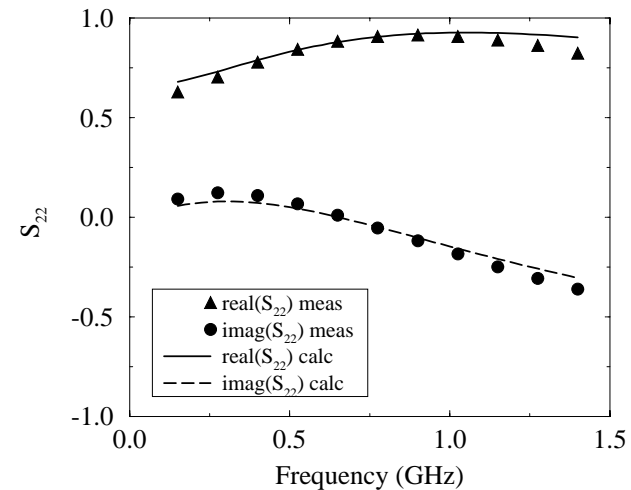
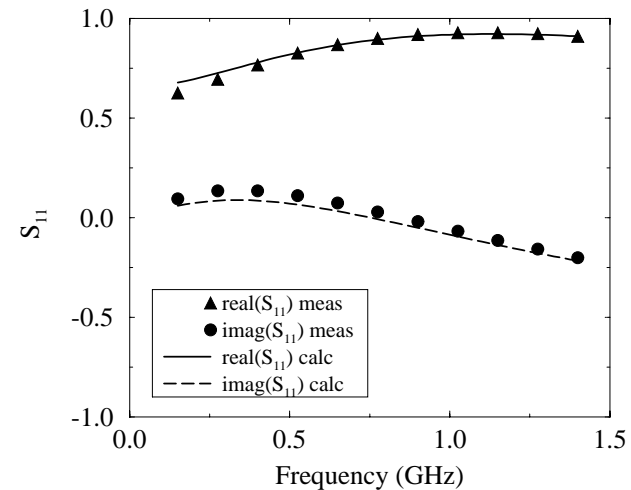
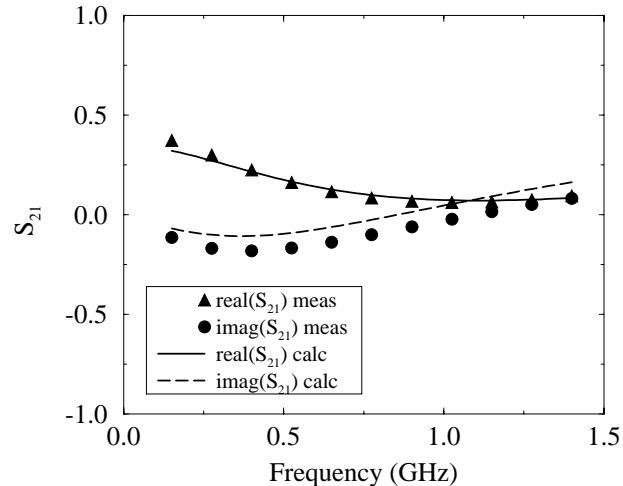
- $OD_o = 290\mu\text{m}$ ,  
 $n_o = 2.5$
- $OD_i = 190\mu\text{m}$ ,  
 $n_i = 4.25$
- $w = 13\mu\text{m}$ ,  $s = 7\mu\text{m}$





# EXPERIMENTAL VERIFICATION: STACKED 1

- Stacked transformer with top spiral overlapping bottom one
- $OD = 180\mu\text{m}$ ,  $n = 11.75$ ,  
 $w = 3.2\mu\text{m}$ ,  $s = 2.1\mu\text{m}$
- $x_s = 0\mu\text{m}$ ,  $y_s = 0\mu\text{m}$ ,  
 $d_s = 0\mu\text{m}$



## FUTURE WORK

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- Incorporate inductive coupling to substrate:  
significant in CMOS epi processes
- Improve expressions for the series resistance  
to include proximity effects
- Extend current sheet approach  
to handle non-uniform current distributions

# CONTRIBUTIONS

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- Current sheet approach to inductance calculation
- Simple accurate expression for inductance of square, hexagonal, octagonal and circular spirals
- Expressions for mutual inductance and mutual coupling coefficient
- On-chip transformer models
- Basis for design and synthesis of on-chip inductor and transformer circuits
- Shunt-peaked amplifier with optimized on-chip inductor

# SO WHAT ?

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- Design
  - { Scalable, analytical models for synthesis and optimization
  
- Verification
  - { Field solvers